

Signatures of quantum critical behavior in disordered TiN thin films (and wires)

arXiv:1806.01335



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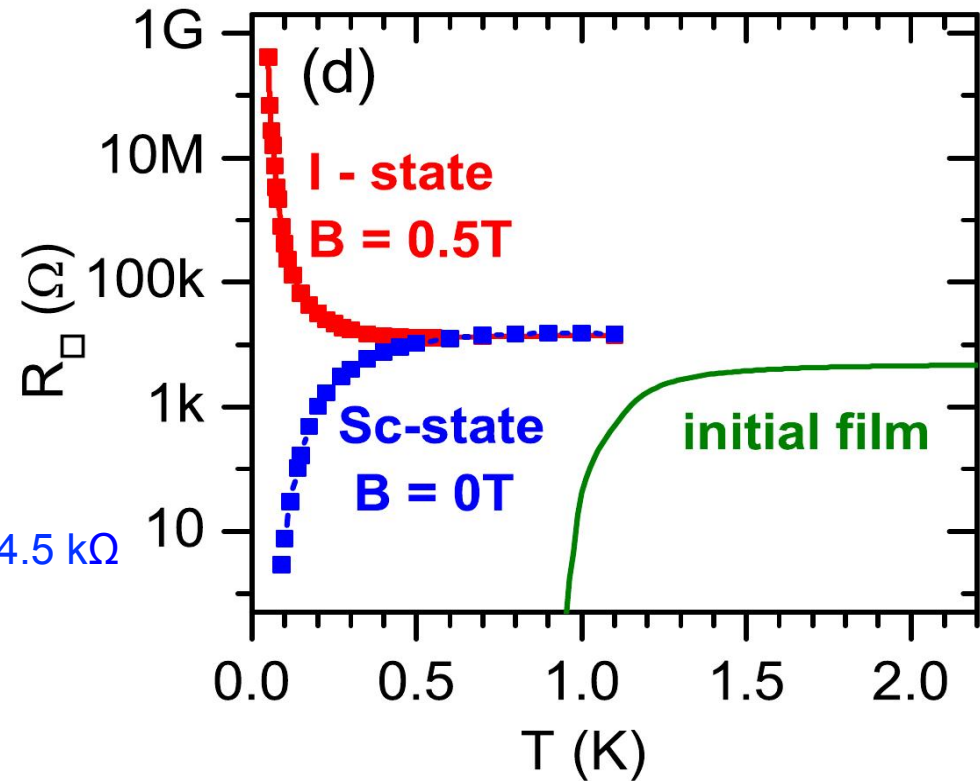
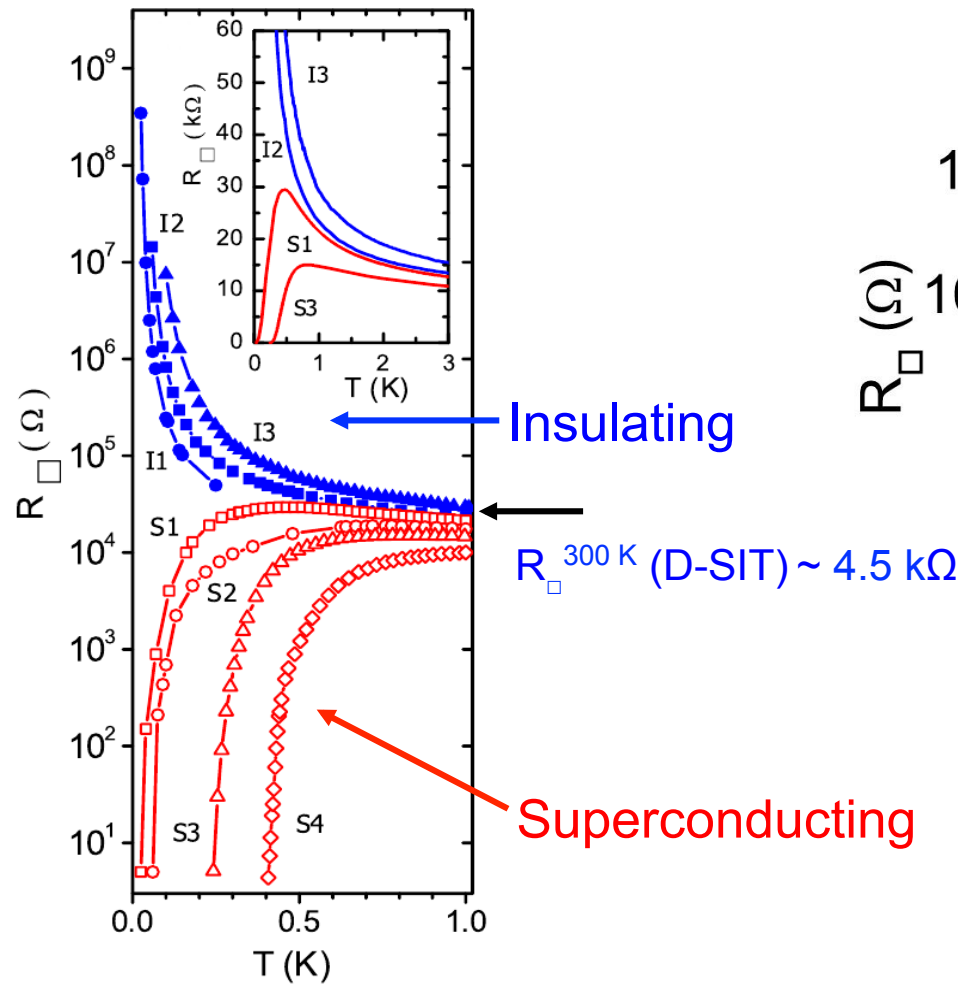
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Superconductor-insulator transition (SIT) in TiN films

Disorder-driven SIT (D-SIT) ($B = 0$) **Field-driven SIT (B-SIT) ($B > 0$)**



gentle increase of resistivity by ion milling or oxidation in air

B-induced SIT as a quantum phase transition

- M. Fisher: apply dimensional analysis to B-SIT
- **Duality** between superconducting (**S**) and insulating (**I**) states:
 - **S: Cooper-pair condensate** (localized vortices)
 - **I: Bose-fluid of unbound vortices** (localized Cooper-pairs)
- Around B_c the resistance should satisfy the scaling form:

$$R = R_c \cdot f[(B - B_c)/T^{1/z\nu}]$$

with a dimensionless scaling function f , and the scaling exponent $z\nu$

(ν : correlation length exponent, z : dynamical exponent)

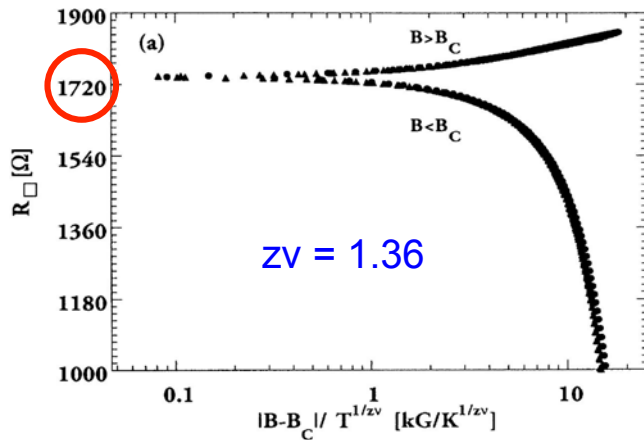
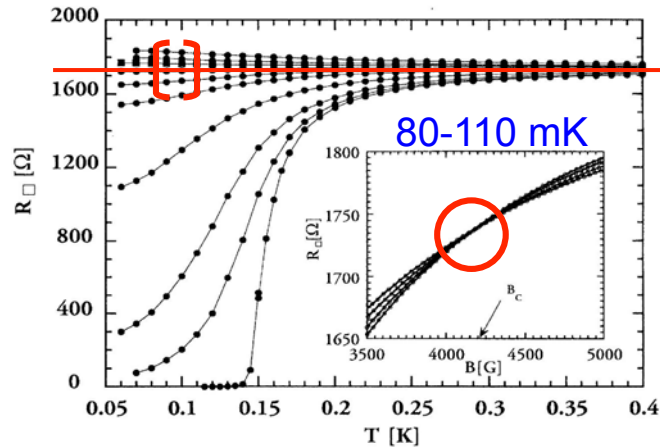


**Search for crossing points in the
magnetoresistance isotherms**

Crossing points in the magnetoresistance isotherms

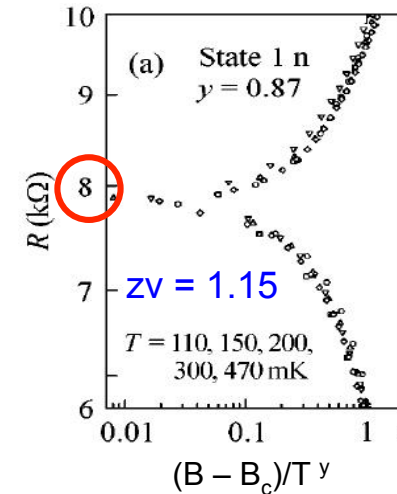
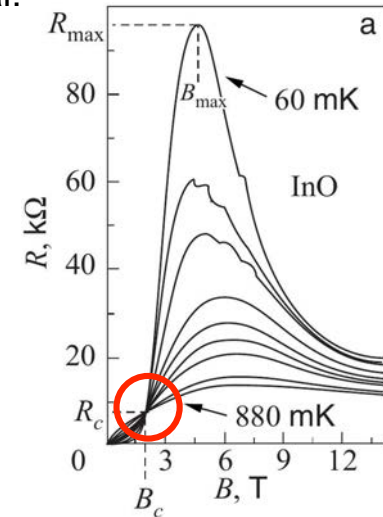
Amorphous MoGe

A. Yazdani and A. Kapitulnik
 Phys. Rev. Lett. **74**, 3037 (1994)



Amorphous indium oxide

V. F. Gantmakher et al.
 JETP **71**, 473 (2000)



Plateau in the $R(T)$ curve
 at the crossing field B_c

Crossing point in the
 magnetoresistance isotherms

Collapse of the $R(B)$ isotherms
 in scaling plots with adjusted zv

very different strength of
 insulating behavior

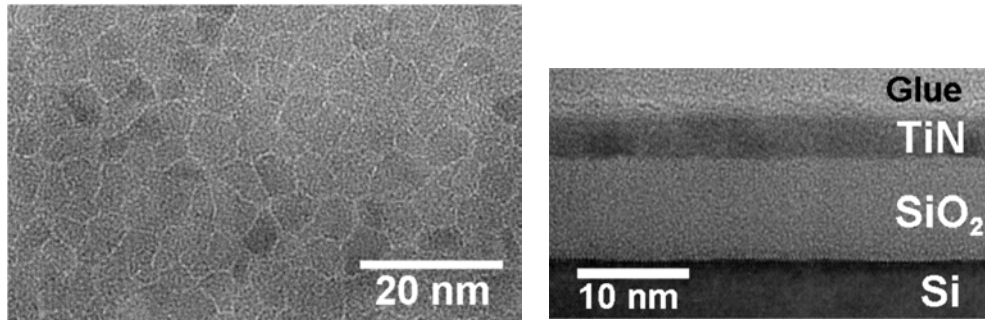
no universal critical
 resistance

Outline:

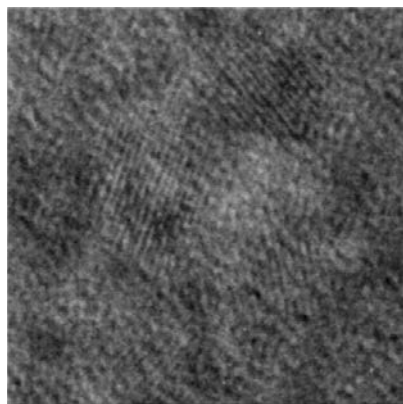
- crossing points in the magnetoresistance of TiN thin films
- critical behavior of the B-induced SIT
near the disorder-induced SIT
- self-induced granularity
- Josephson-like *superconducting* and Bloch-like *insulating*
behavior in **narrow nanowires**

Film characteristics

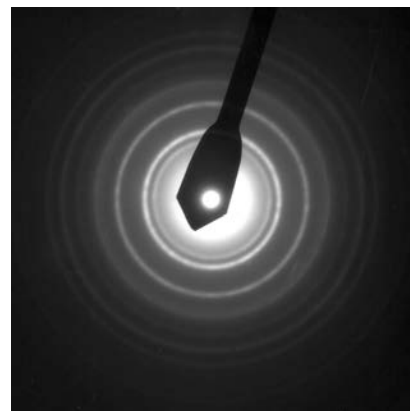
T. I. Baturina, C.S. et al.,
Appl. Phys. Lett. **102** (2013)



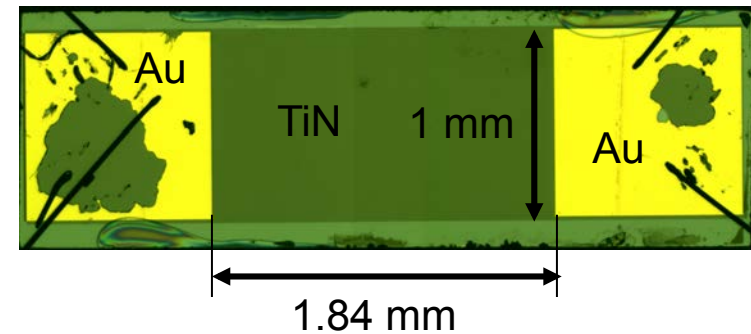
- ultrathin TiN films with thickness $d = 3.6$ nm
atomic layer deposition at 400 °C
- polycrystalline structure



14 nm



Sample D03_S



$3.5 \text{ k}\Omega < R_{\square}^{300 \text{ K}} < 4.5 \text{ k}\Omega$
tuned by heating in air

properties of untreated film:

$$R_{\square}^{300 \text{ K}} = 2.52 \text{ k}\Omega$$

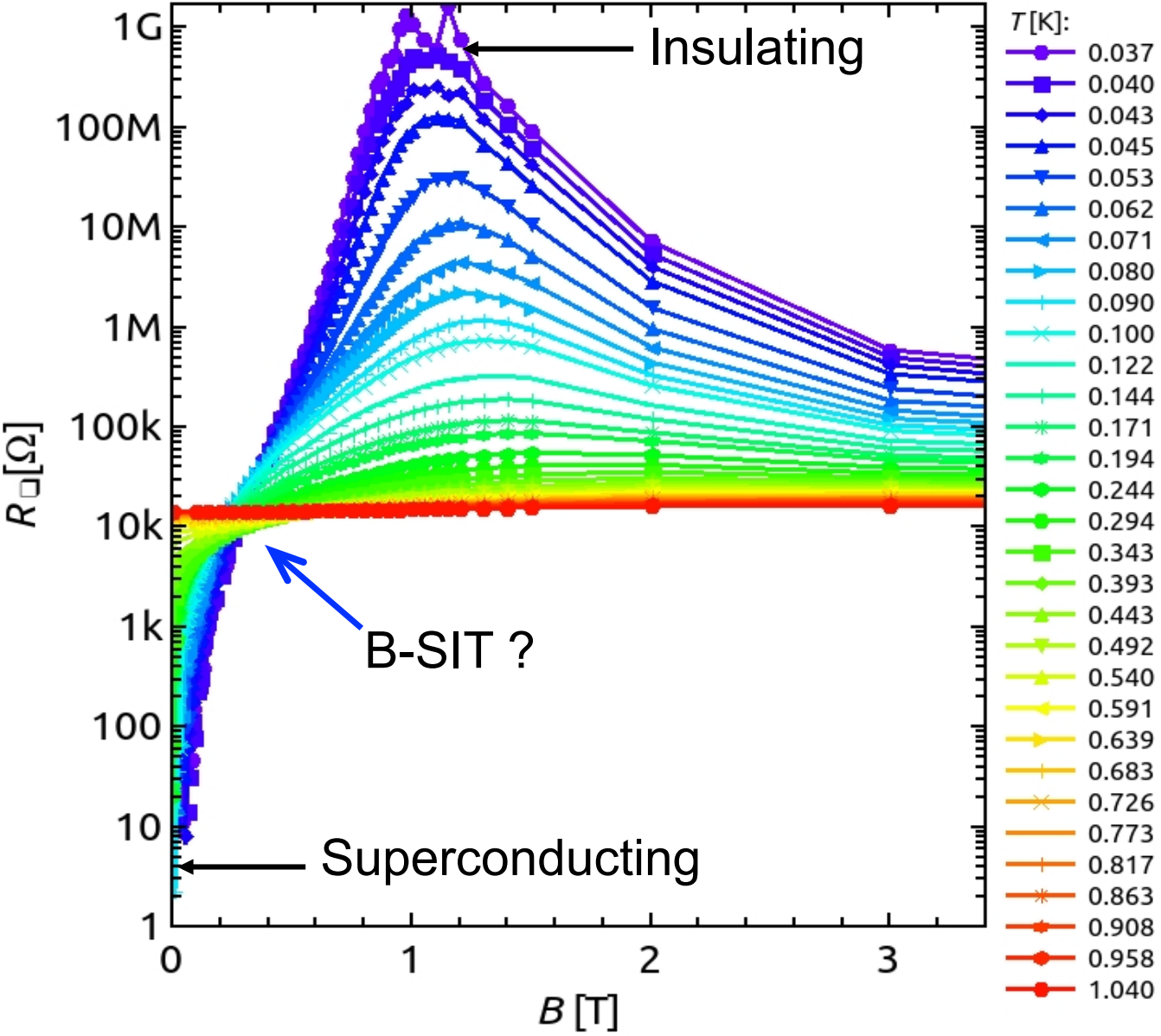
$$T_c = 1.29 \text{ K}$$

$$\xi_d(0) = 8.9 \text{ nm}$$

$$D = 0.34 \text{ cm}^2/\text{s}$$

$$n = 1.5 \cdot 10^{22} \text{ cm}^{-3}$$

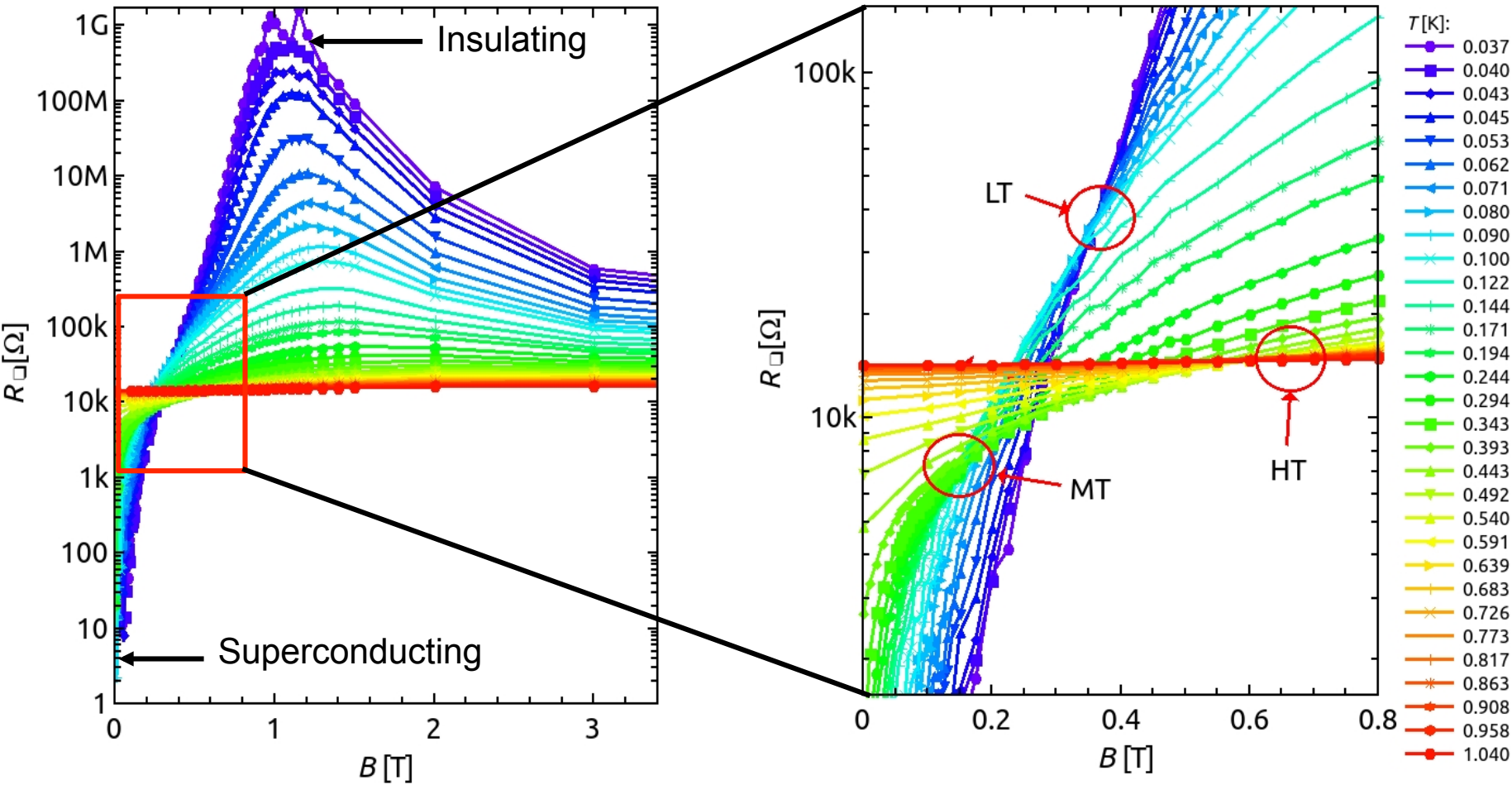
Magnetoresistance in critically disordered TiN films



similar to phenomenology in InO

blurred crossing of magnetoresistance isotherms

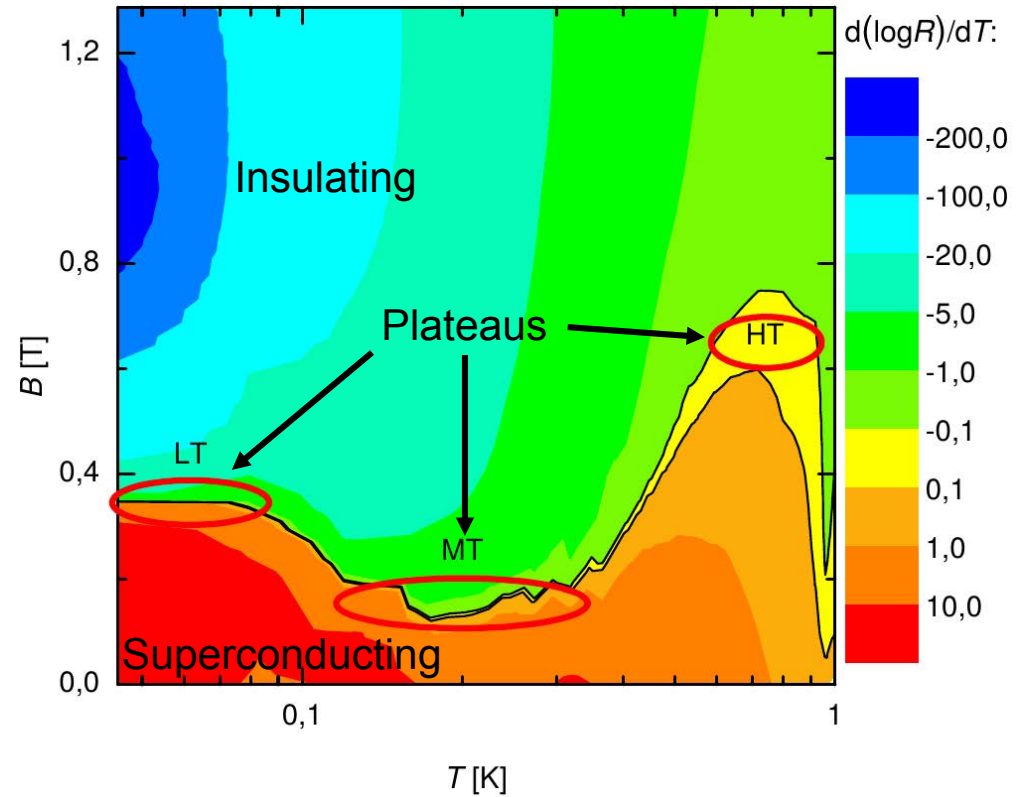
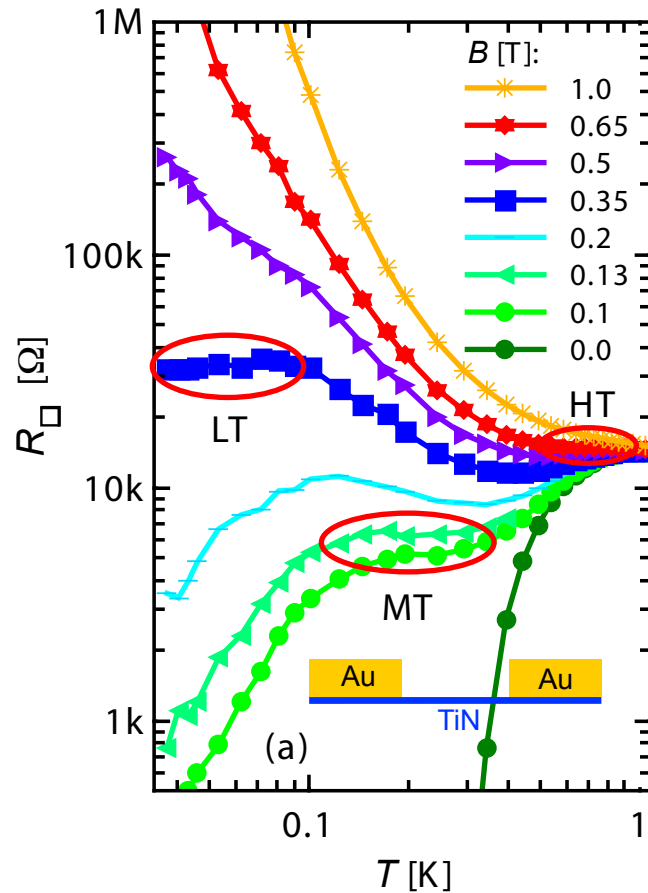
Magnetoresistance in critically disordered TiN films



we find three crossing (*isosbestic*) points, where $R(B)$ s intersect!

← Greger, Kollar, Vollhardt, PRB **87** (2013)

Crossing points yield plateaus in the R(T) curves

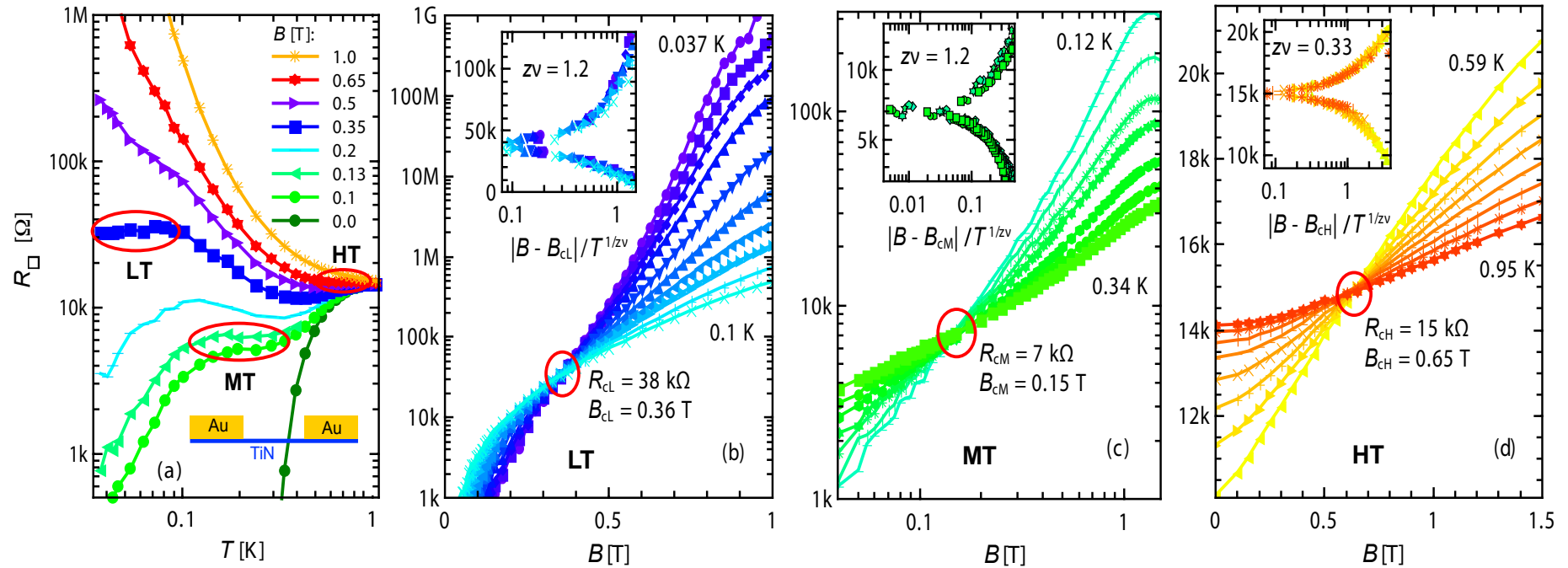


three distinct crossing point in R(B) isotherms -
 what about quantum phase transitions?



**scaling
 analysis**

Crossing points yield plateaus in the $R(T)$ curves

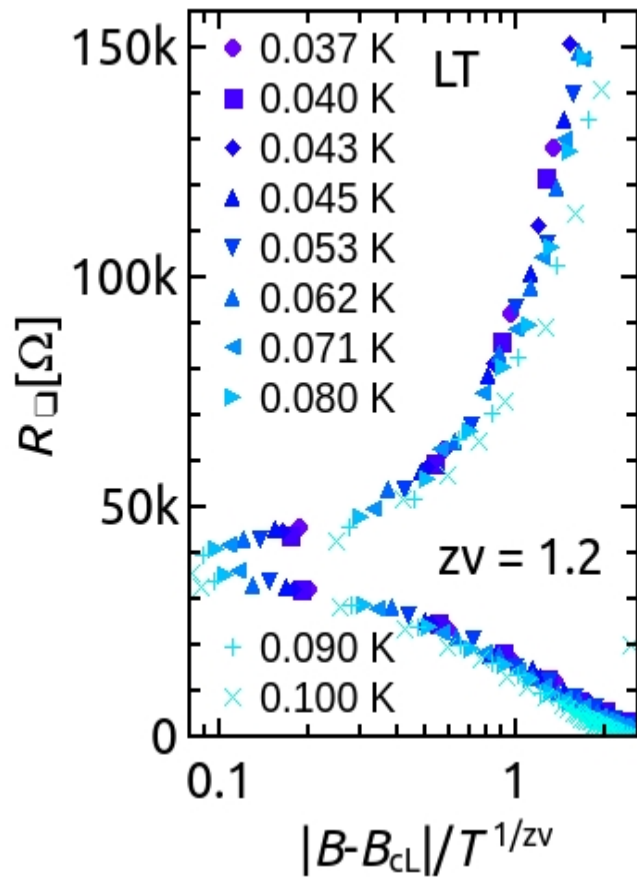


three distinct crossing point in $R(B)$ isotherms -
 what about quantum phase transitions?

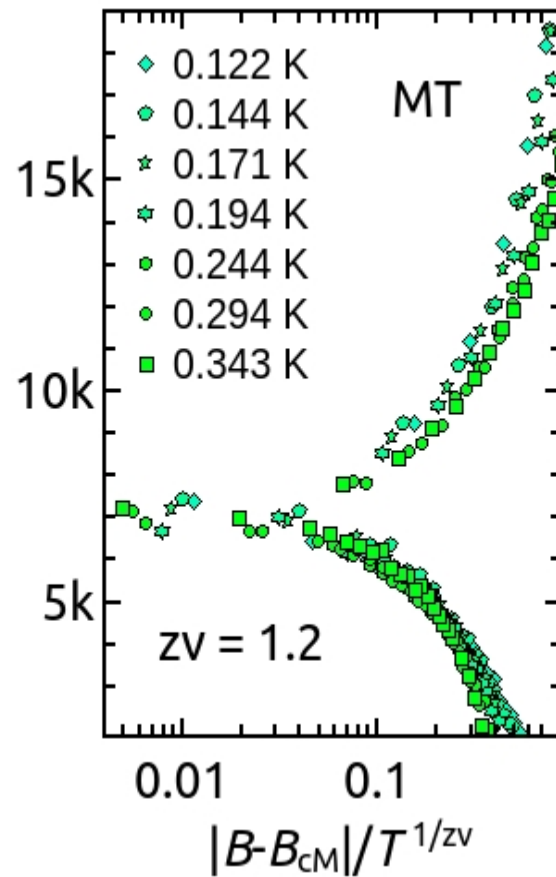


**scaling
 analysis**

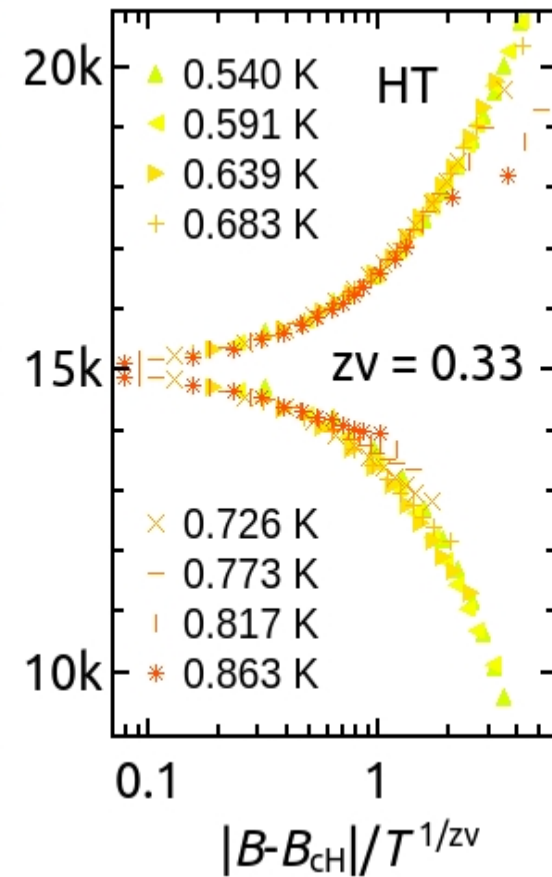
Scaling analysis



LT crossing point



MT crossing point



HT crossing point:

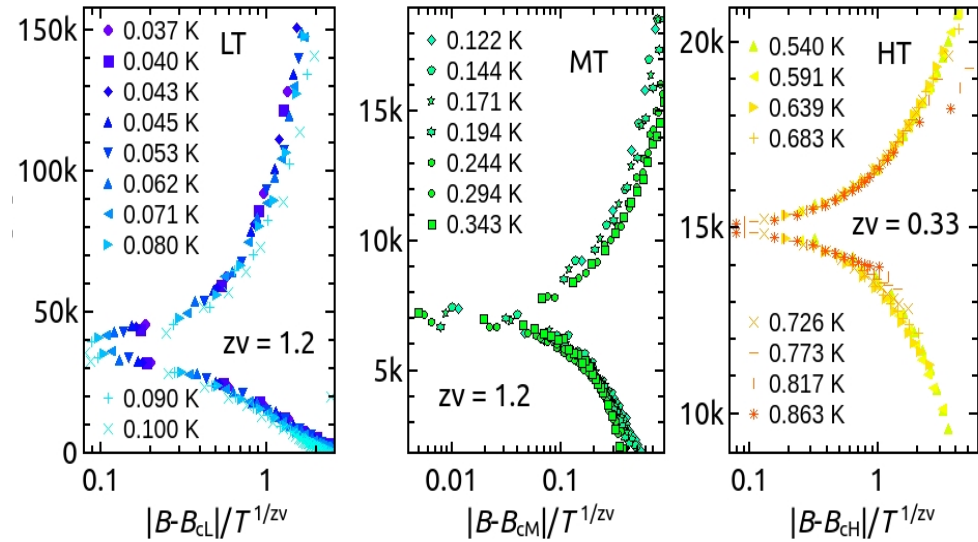
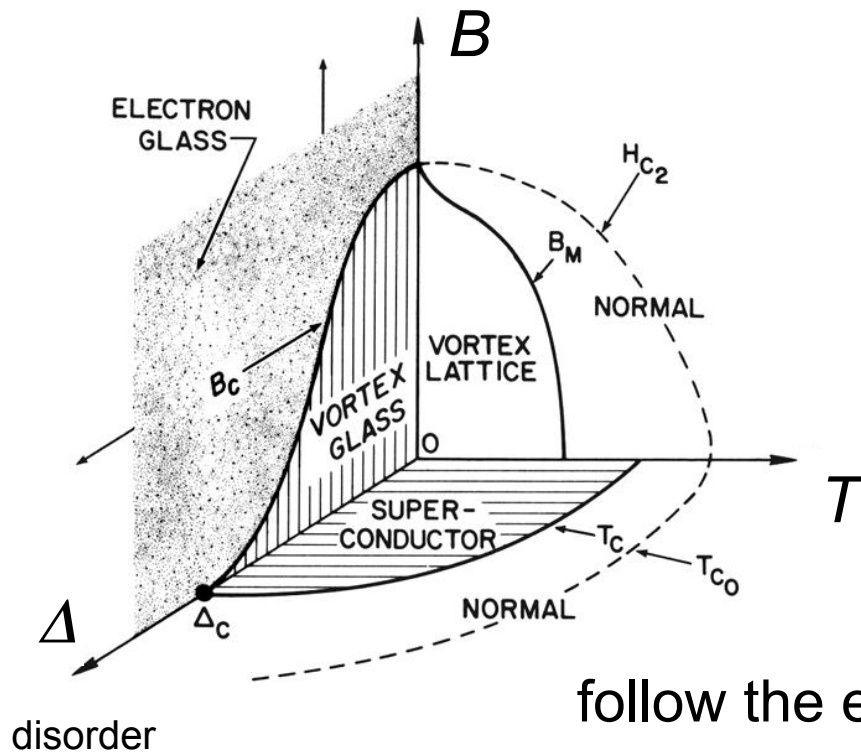
$zv = 1.2$ consistent with theoretical prediction of $zv \geq 1$ for a SIT in a disordered system [M. P. A. Fisher, PRL **65**, 7 (1990)]



Where is the SIT?

how to identify universal behavior?

phase diagram Fisher:

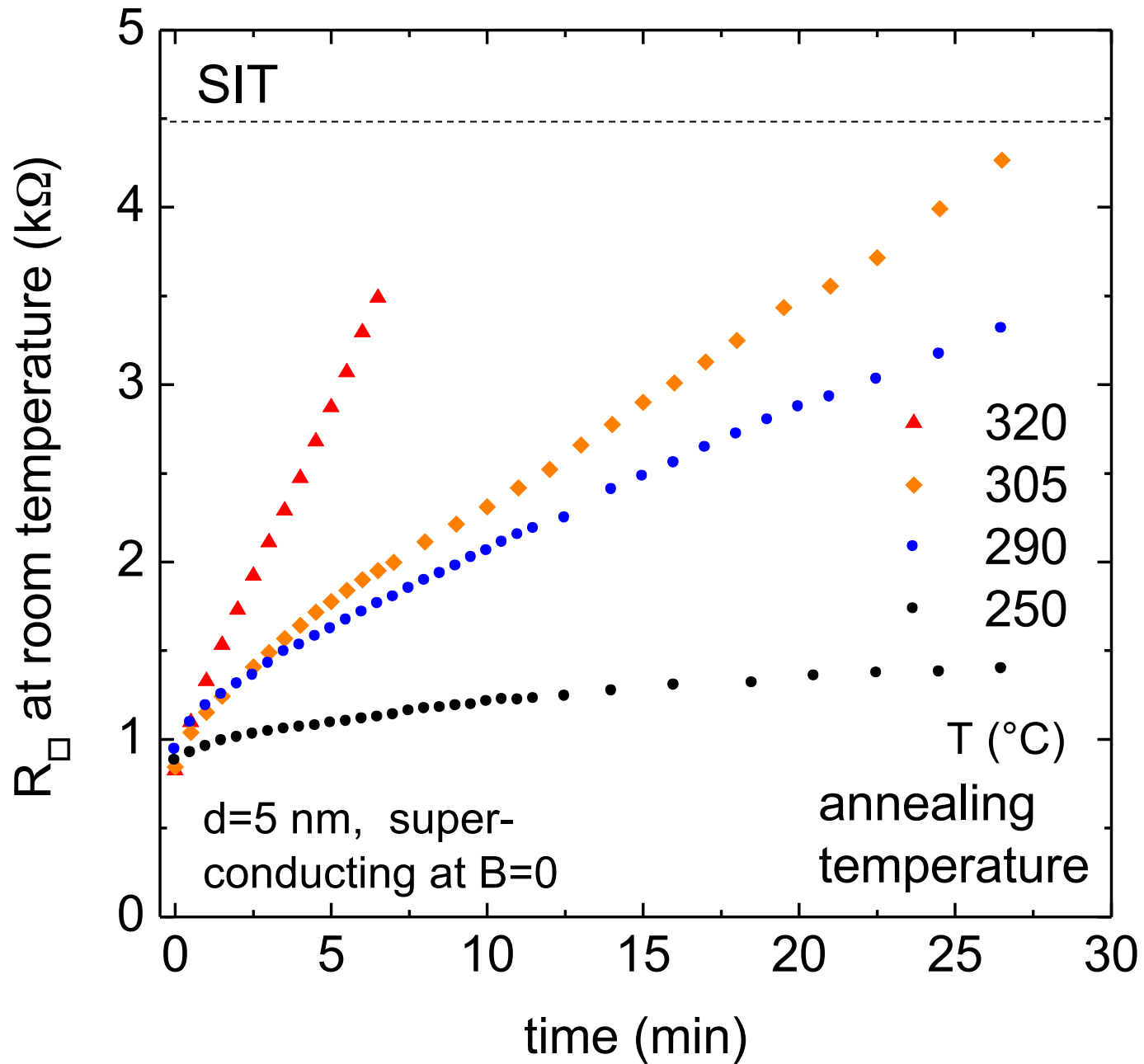


follow the evolution of the critical parameters for the B-induced SIT, when approaching the disorder-induced SIT

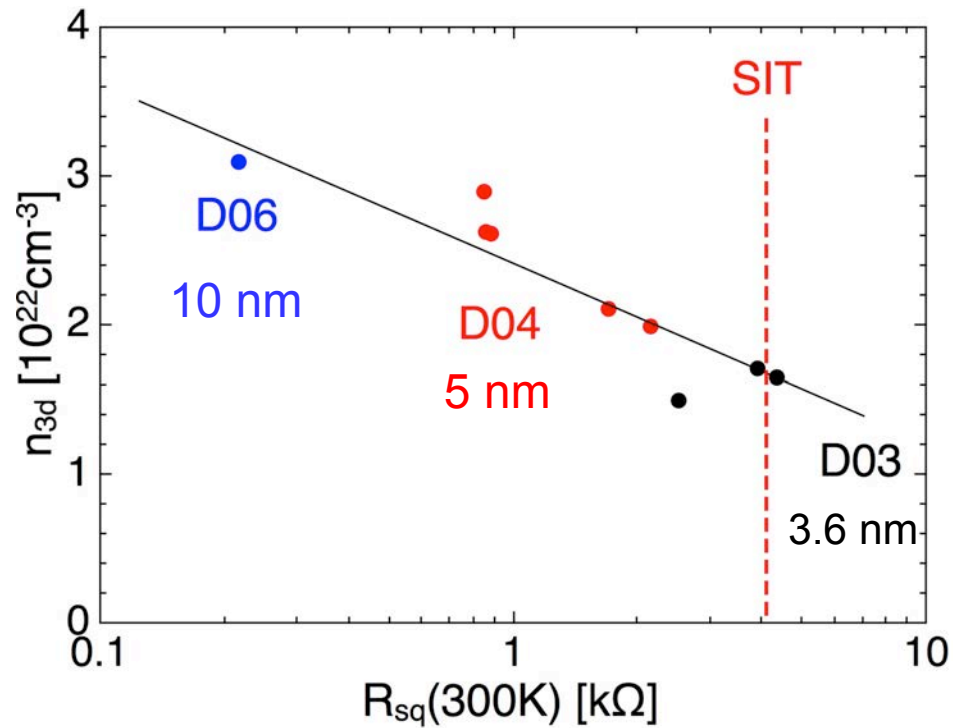
Fisher, PRL **65**, (1990)

see talk J. Lesueur

controlled oxidation of TiN films in air

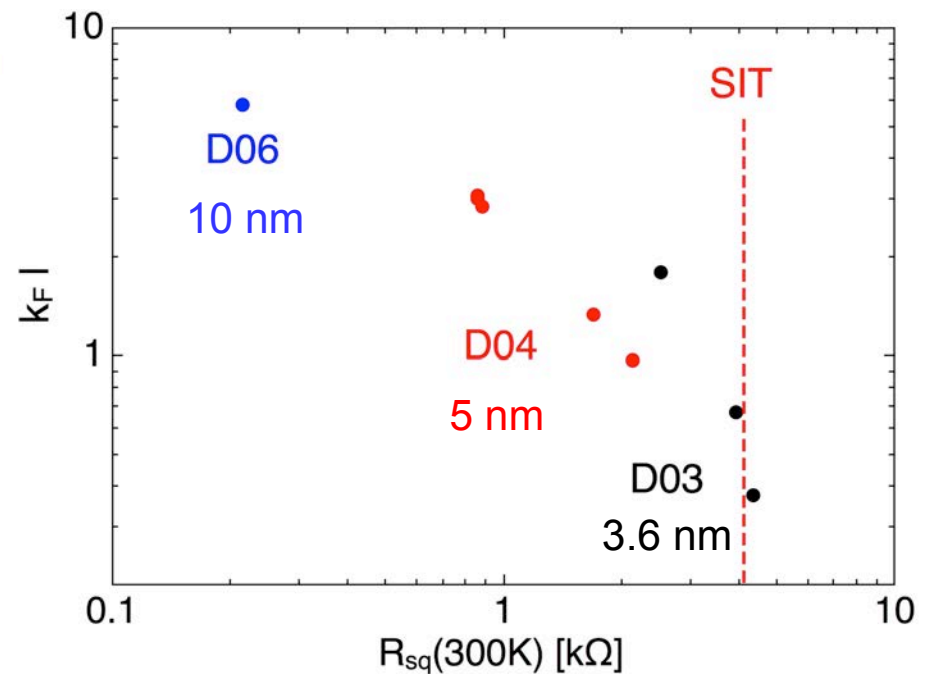


controlled oxidation of TiN films in air

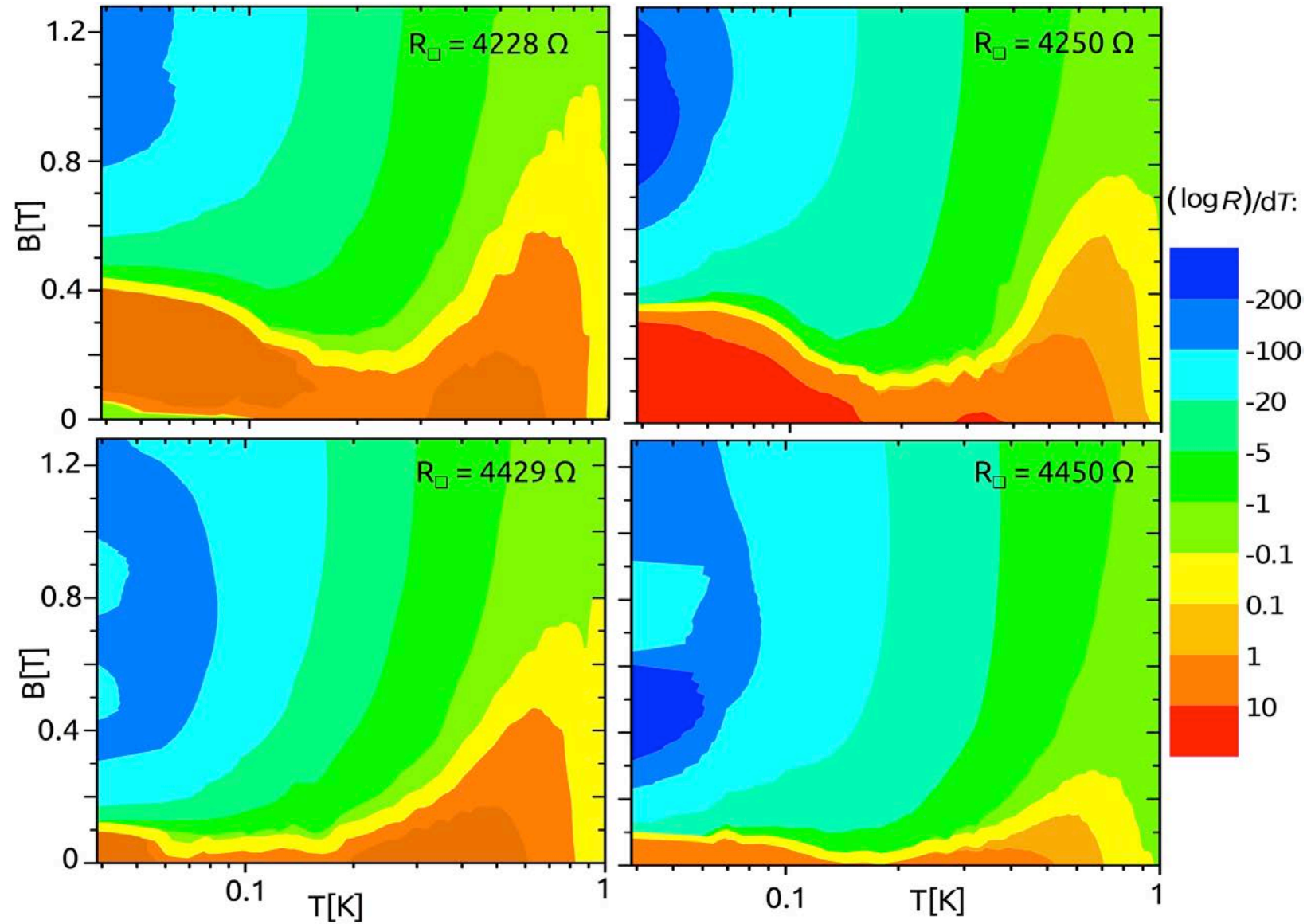


carrier density is metallic
and changes only by factor 2

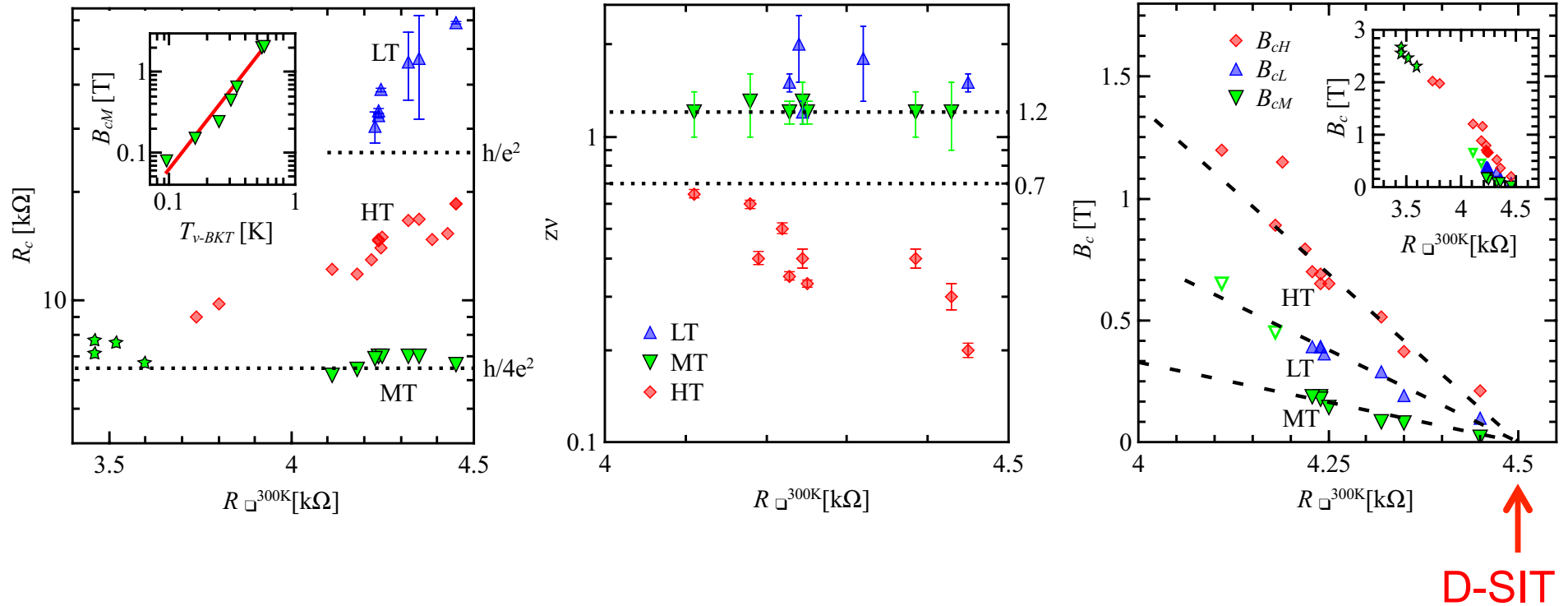
SIT occurs near $k_{F|} \sim 1$



Evolution of SIT separatrix



Evolution of scaling parameters near SIT



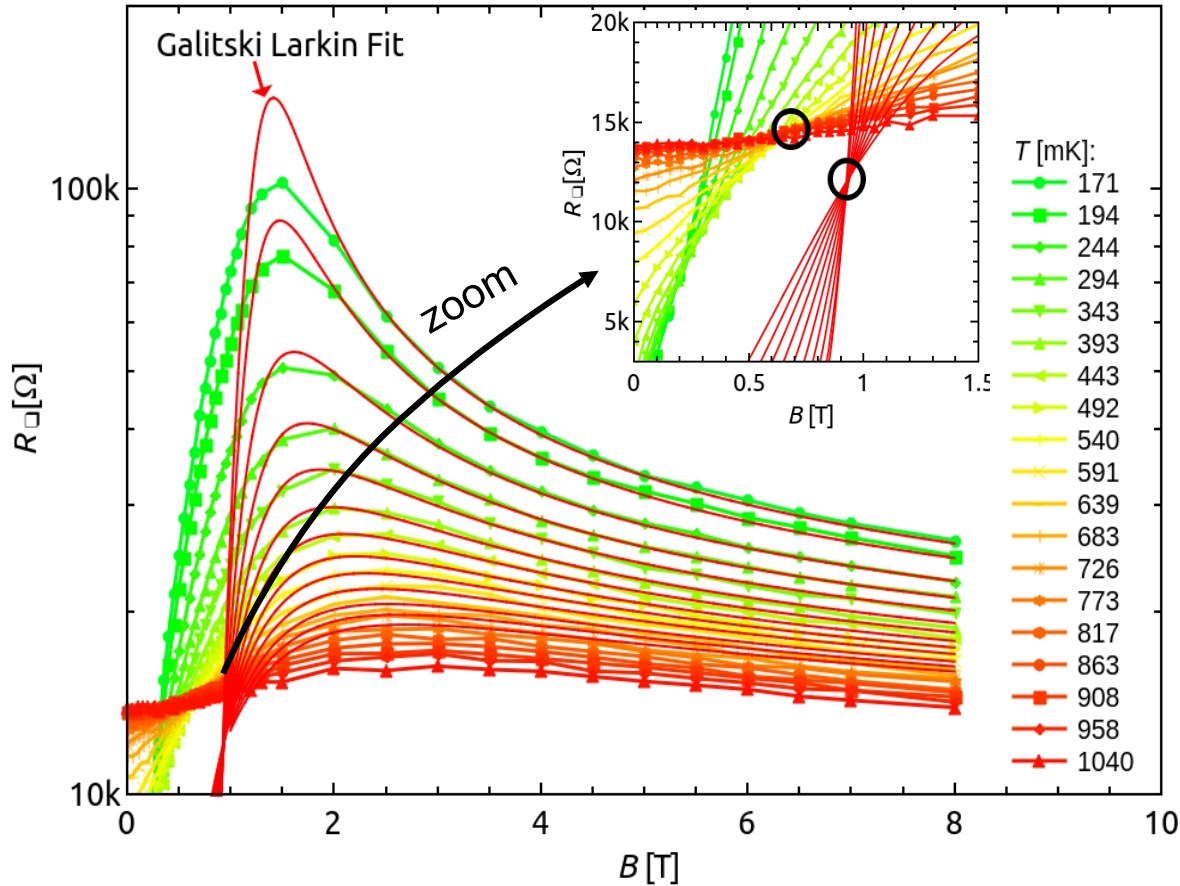
- only MT crossing point produces universal values of R_c and $z\nu$!
- B_c values converge towards zero at critical resistance for D-SIT



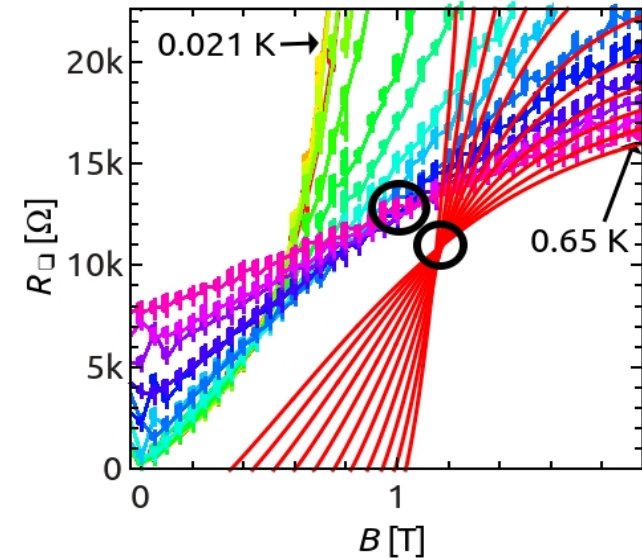
intermediate plateau in $R(T)$ may correspond to Fisher scenario

high T regime: superconducting fluctuations above B_{c2}

$R_{\square}^{300\text{ K}} = 4.25\text{ k}\Omega$



Less disordered sample:
 $R_{\square}^{300\text{ K}} = 4.18\text{ k}\Omega$



theory by
 Galitski & Larkin, PRB **63**, (2001)



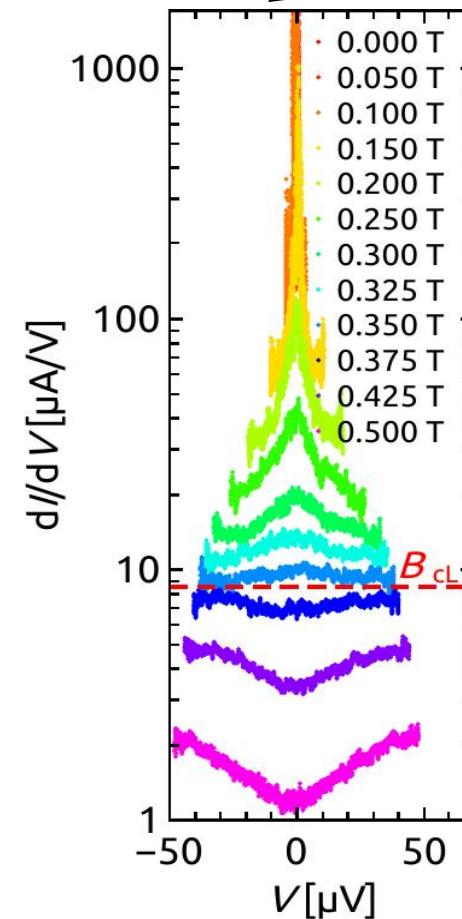
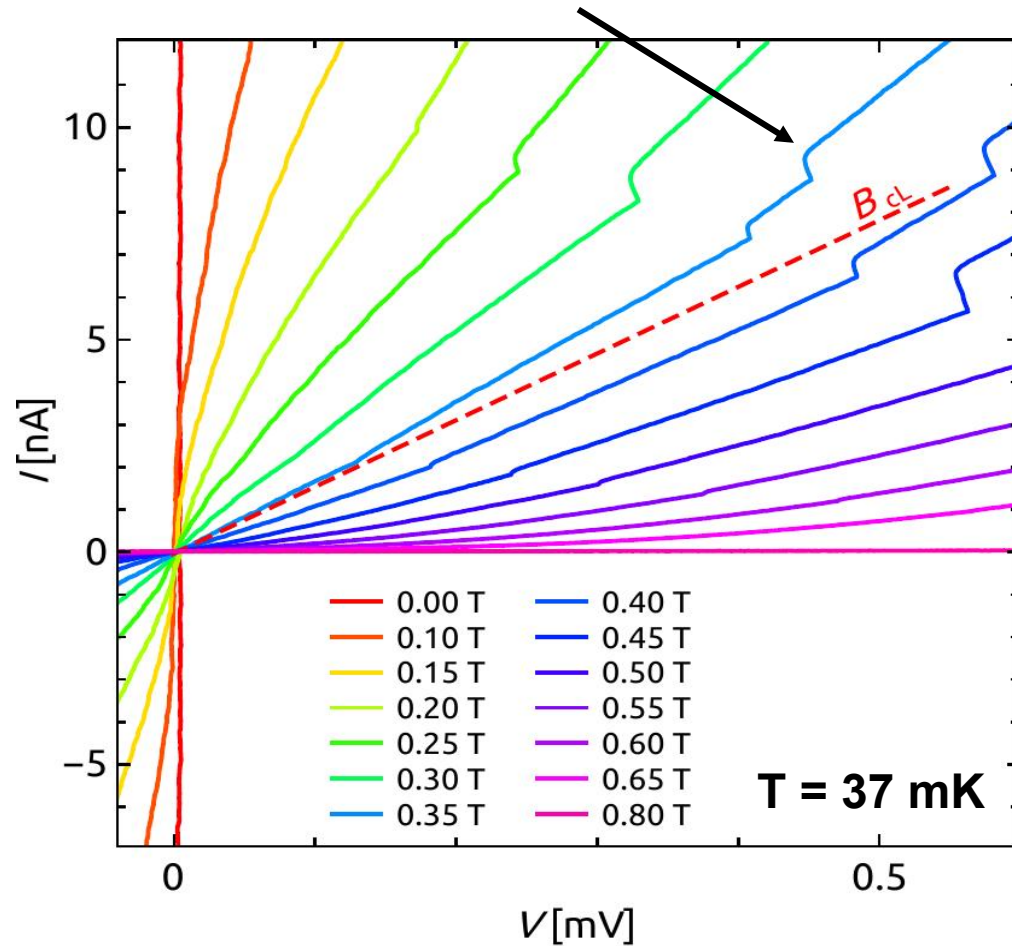
no quantum phase transition required to understand this particular isosbestic point

low T regime: signatures of mesoscopic inhomogeneities

Insulating and superconducting features **coexist** for $0.2 \text{ T} \leq B < B_{\text{cl}} = 0.36 \text{ T}$

current jumps at higher voltage for $B \geq 0.2 \text{ T}$
found also in InO [O. Cohen et al., PRB **84**, (2011)]

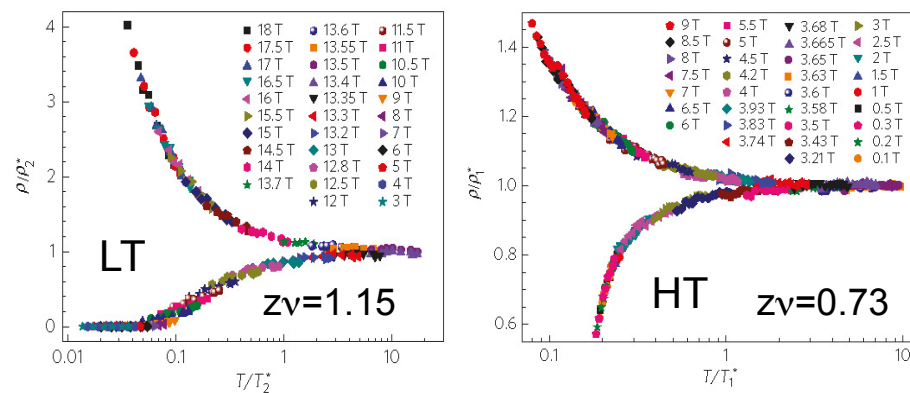
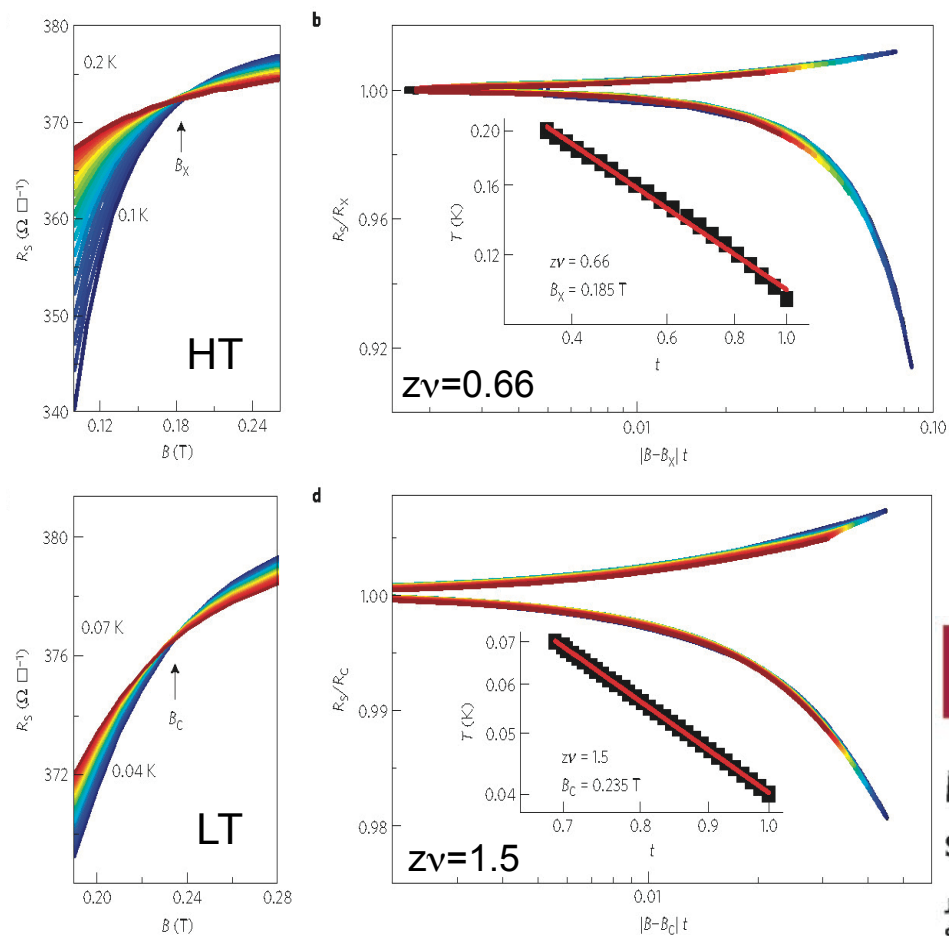
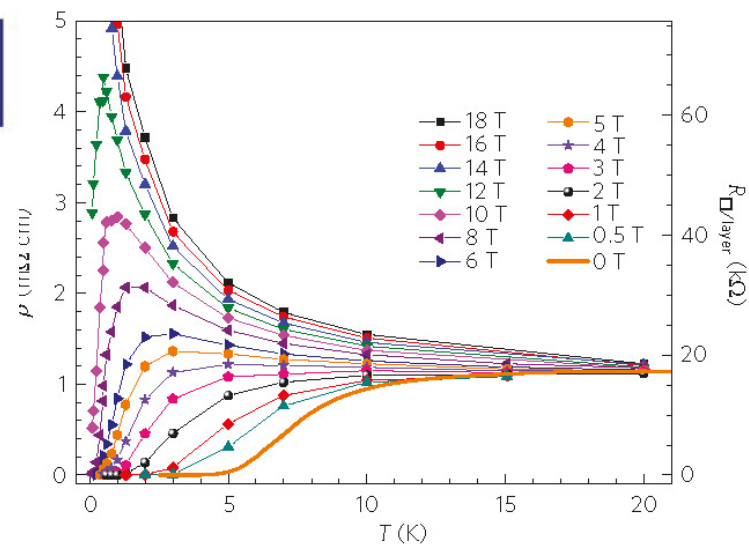
diverging dI/dV
around zero bias for $B < B_{\text{cl}}$



formation of superconducting filaments on a mesoscopic scale

Two-stage magnetic-field-tuned superconductor-insulator transition in underdoped $\text{La}_{2-x}\text{Sr}_x\text{CuO}_4$

Xiaoyan Shi^{1†}, Ping V. Lin¹, T. Sasagawa², V. Dobrosavljević¹ and Dragana Popović^{1*}



Multiple quantum criticality in a two-dimensional superconductor

J. Biscaras¹, N. Bergeal¹, S. Hurand¹, C. Feuillet-Palma¹, A. Rastogi², R. C. Budhani^{2,3}, M. Grilli⁴, S. Caprara⁴ and J. Lesueur^{1*}

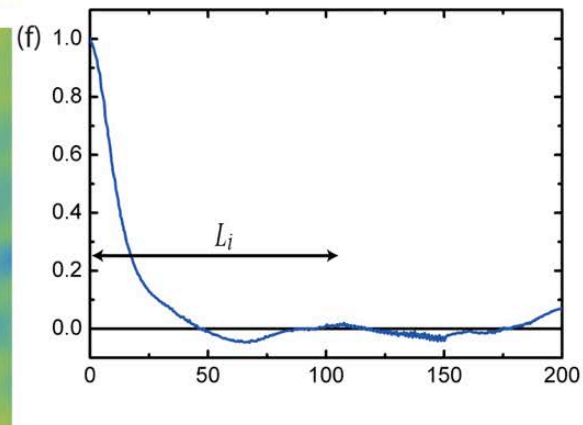
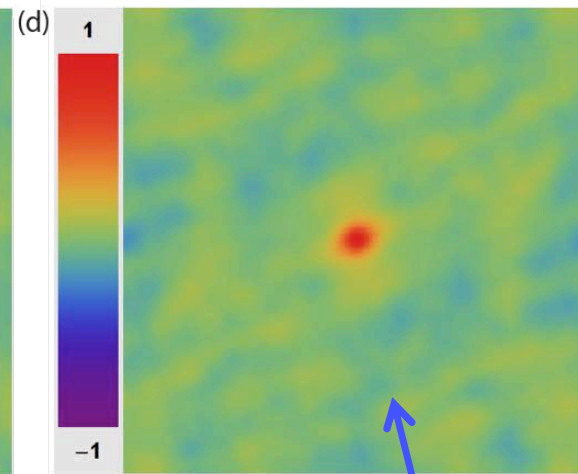
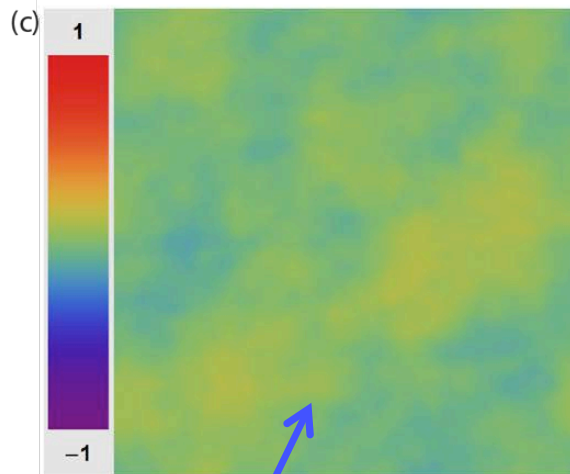
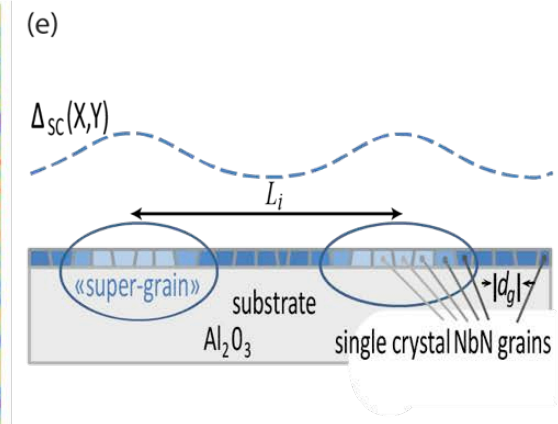
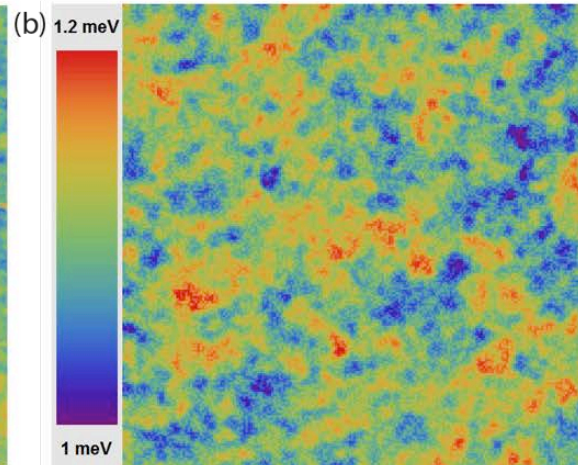
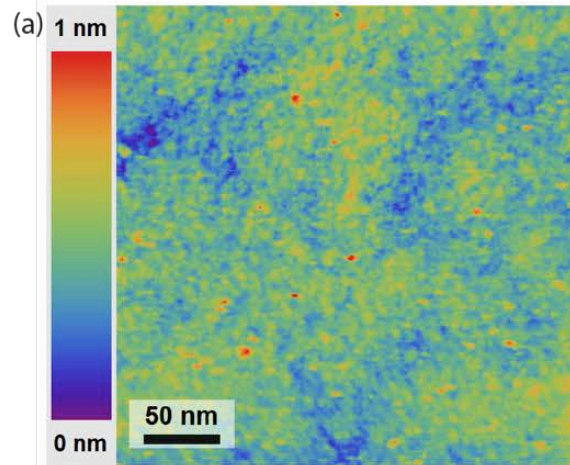
Intermediate conclusion

- Several crossing points in magnetoresistance possible
- Despite very different origins, scaling often possible
- Strong similarities to phenomenology in InO_x
- More direct experimental information (besides $z\nu$) is desirable to **understand specifics of the different phases**:
 - mechanisms of conduction and insulation
 - is there a 'vortex Bose condensate' ?
 - use 2nd control parameter to check for universality!
 - features of the 'normal metal' at the critical point?

emergent electronic granularity in NbN

topography

density of states



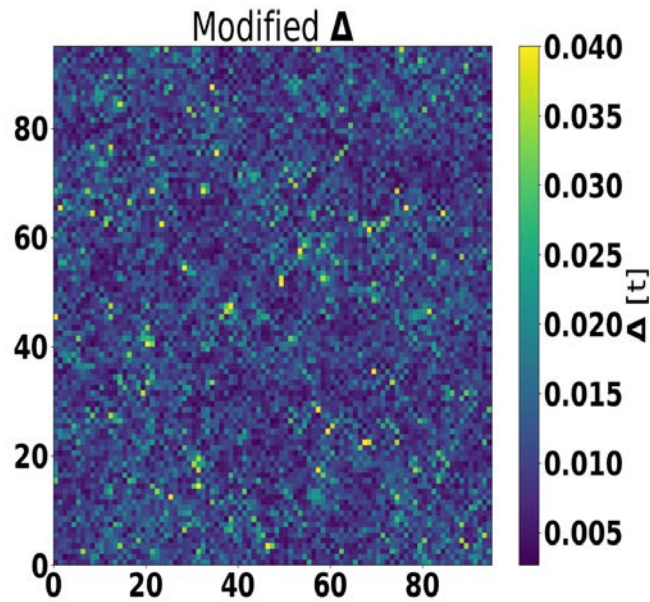
no cross-correlation between topography and electronic granularity

auto-correlation of electronic granularity

C. Carbillet et al., PRB 93, 144509 (2016)

Roditchev group,
INSP Paris

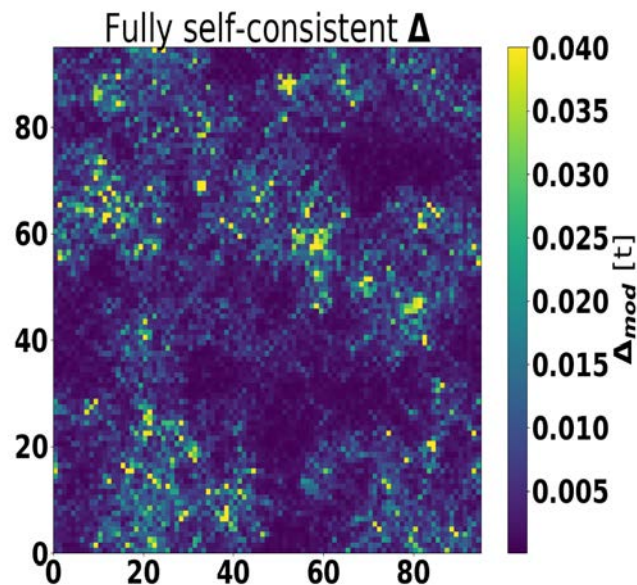
Numerical calculation of $\Delta(r)$ in presence of strong disorder



Pairing amplitude in real space the for a specific disorder configuration on a 96x96 lattice:

simplified self-consistency scheme

following Feigel'man, Ioffe, Kravtsov, Cuevas, Ann. Phys. 325, 1368 (2010)



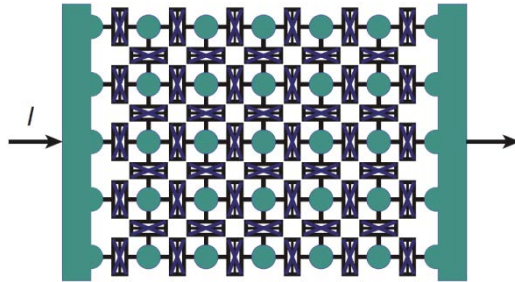
fully self-consistent scheme

(see also Bouadim et al., Nat. Phys. 2011)

(same disorder and parameter configuration, phase fluctuations neglected)

calculations by M. Stosiek, F. Evers

superconductor-insulator transition in TiN thin films



V. M. Vinokur et al., Nature **452**, 613-615 (2008)

model system: Josephson junction arrays

Quantum phase transitions and vortex dynamics in superconducting networks

Rosario Fazio^{a,b,*}, Herre van der Zant^c

Phys. Rep. 355, 4 (2001) 235-334

two competing energy scales: **Josephson coupling energy E_J** vs. **charging energy E_C**

electronic fragmentation in TiN films → self organized superconducting islands

random Josephson junction array?

TiN: Sacépé et al., Phys. Rev. Lett. **101**, 157006 (2008)

NbN: Patel et al., Phys. Rev. B **80**, 012504 (2009), Carbillet et al., 93, 144509 (2016)

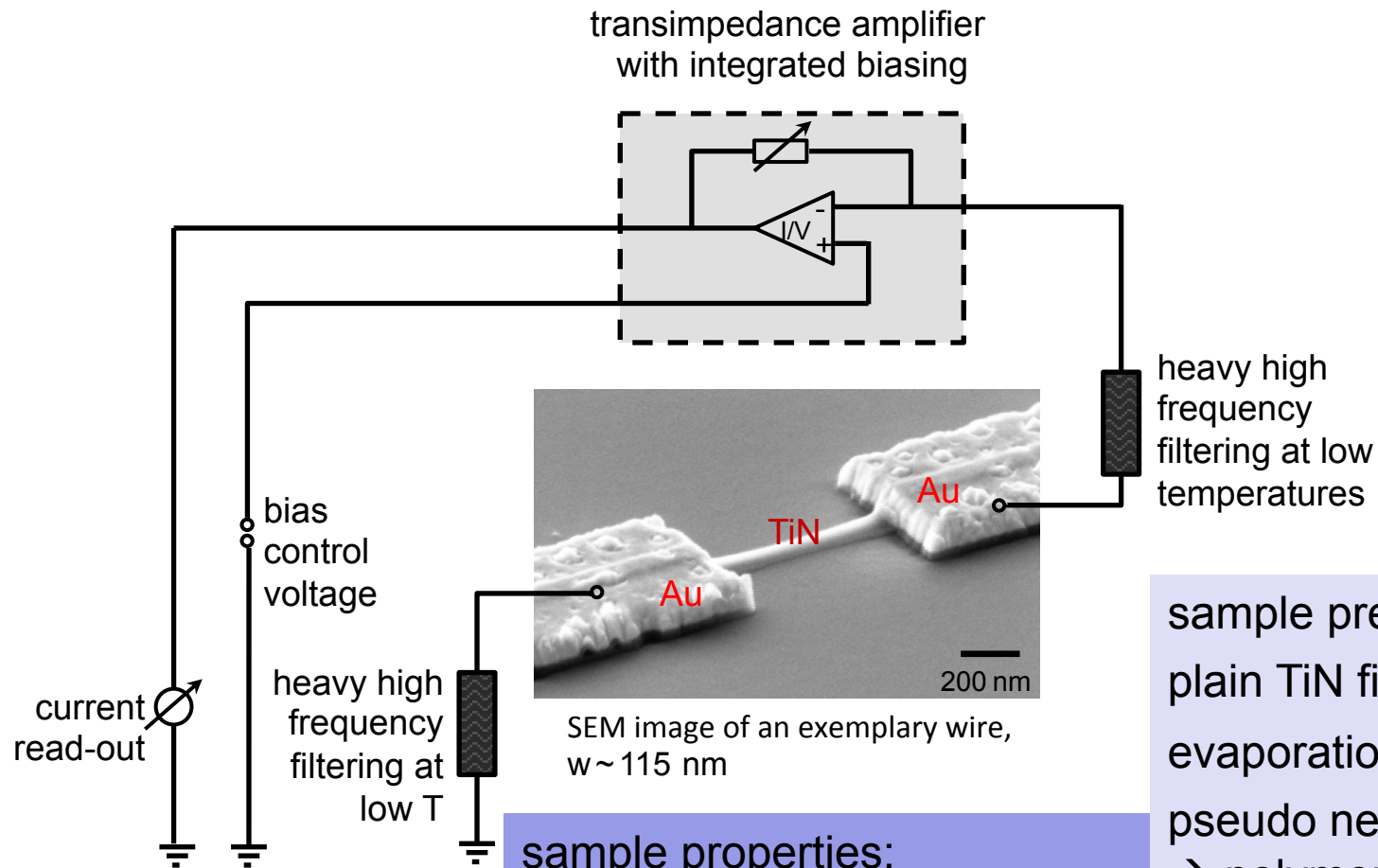
InO: Sacépé et al., Nat. Phys. **7**, 239 (2011)

Questions:

1. Is the superconductor-insulator transition in TiN thin films an effect of
electronic fragmentation?

2. Can we find signatures of electronic fragmentation in submicron samples?

Sample layout and measurement setup

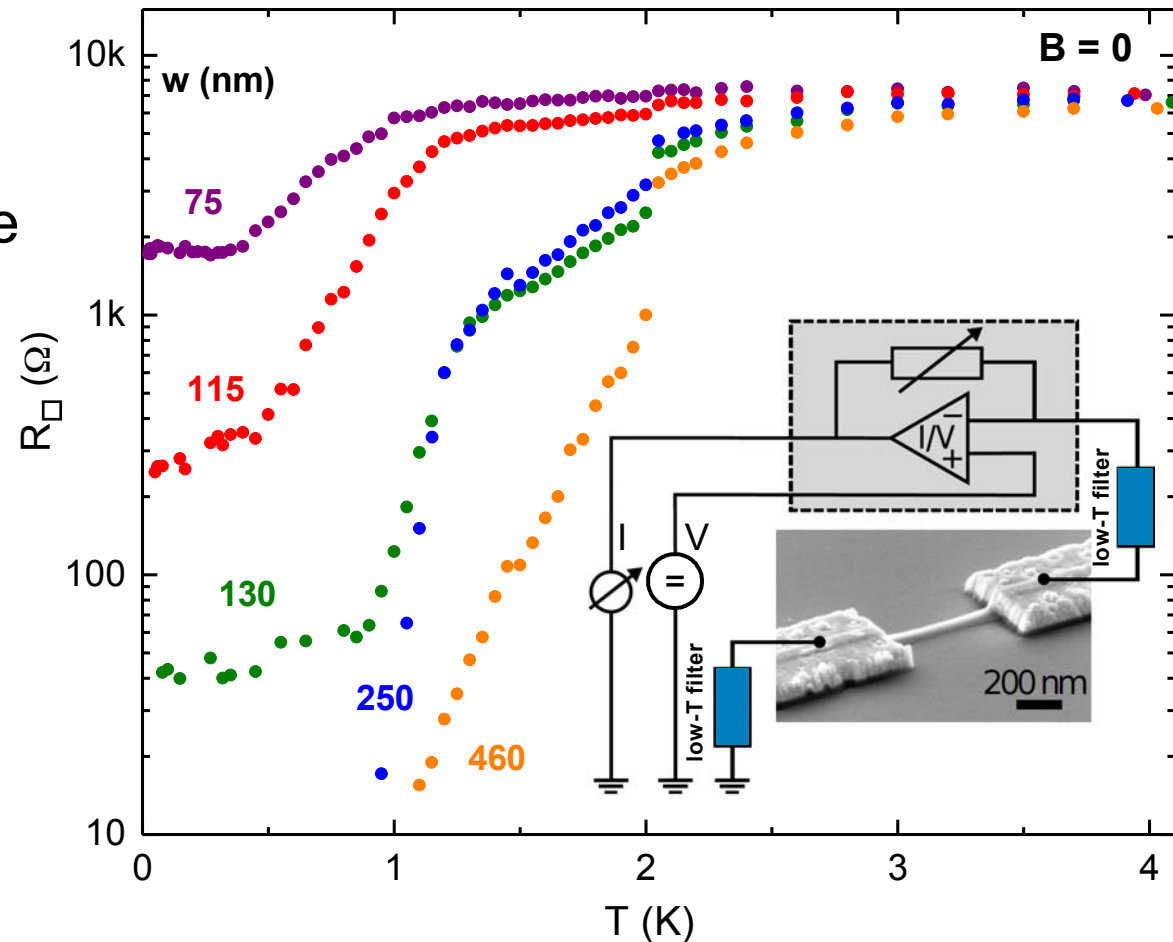


sample properties:
fixed length $l \sim 800$ nm
varying widths $w \sim 75$ - 800 nm
1-10 squares
 $R_{300K} = 4.3$ k Ω .. 44 k Ω

sample preparation:
plain TiN film deposited by ALD
evaporation of Au contacts
pseudo negative EBL process
→ polymerized PMMA bridge
between contacts
subtractive patterning by argon
ion beam

width dependent saturation behavior in $R(T)$

- ❖ width dependent temperature behavior
- ❖ drop to zero resistance for wide wires
- ❖ saturation behavior for narrow wires
- ❖ suppression of global phase coherence
- ❖ evidence for quantum phase slips



see also

Lau et al., PRL **87**, 217003 (2001)

Arutyunov et al., Phys. Rep. **464**, 1 (2008)

Bollinger et al., PRL **101**, 227003 (2008)

width dependent saturation behavior in $R(T)$

- ❖ width dependent temperature behavior
- ❖ drop to zero resistance for wide samples
- ❖ saturation behavior for small samples
- ❖ suppression of global phase coherence
- ❖ evidence for quantum phase slips

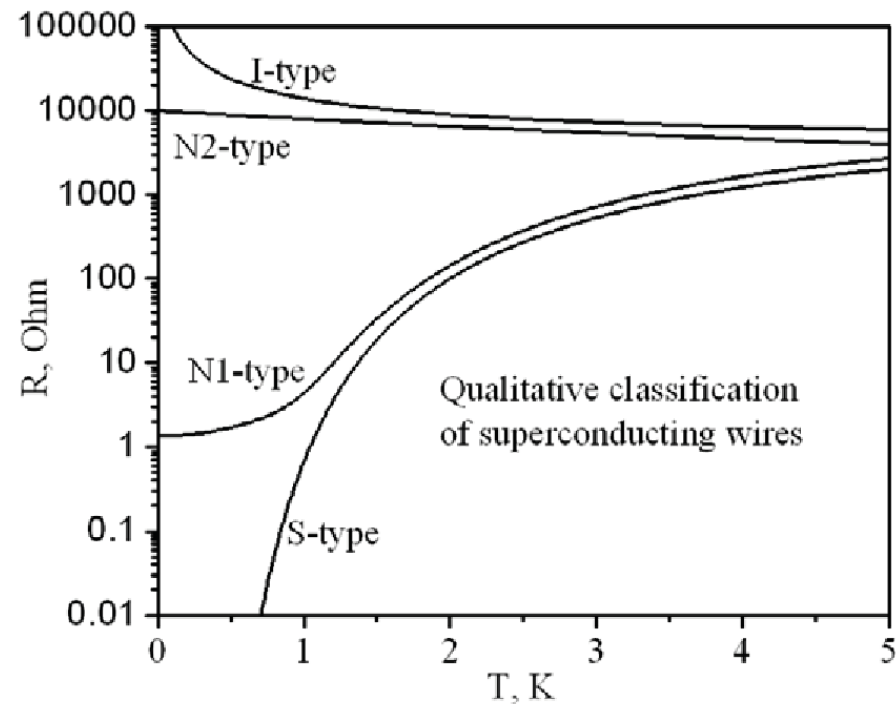
see also

Lau et al., PRL **87**, 217003 (2001)

Arutyunov et al., Phys. Rep. **464**, 1 (2008)

Bollinger et al., PRL **101**, 227003 (2008)

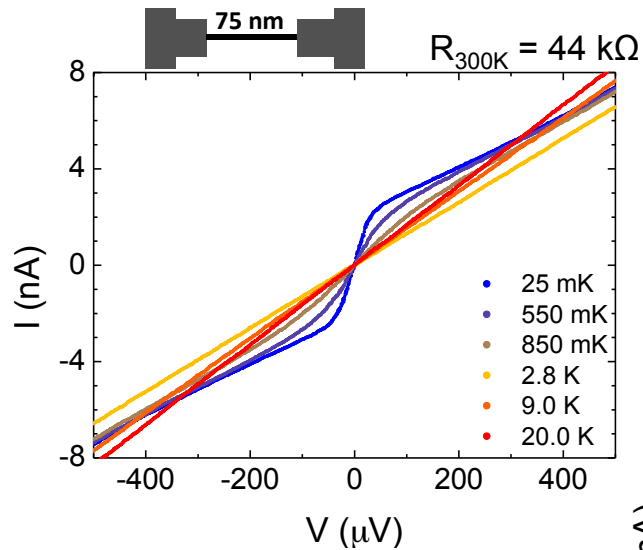
template fabricated α -MoGe nanowires



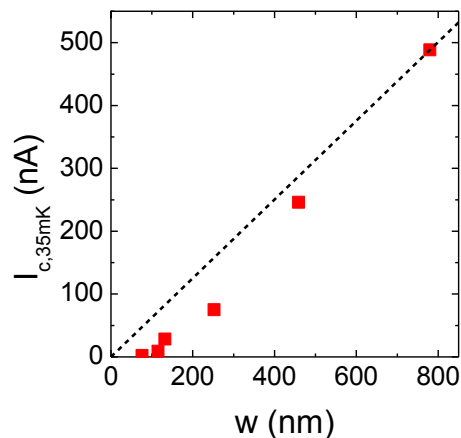
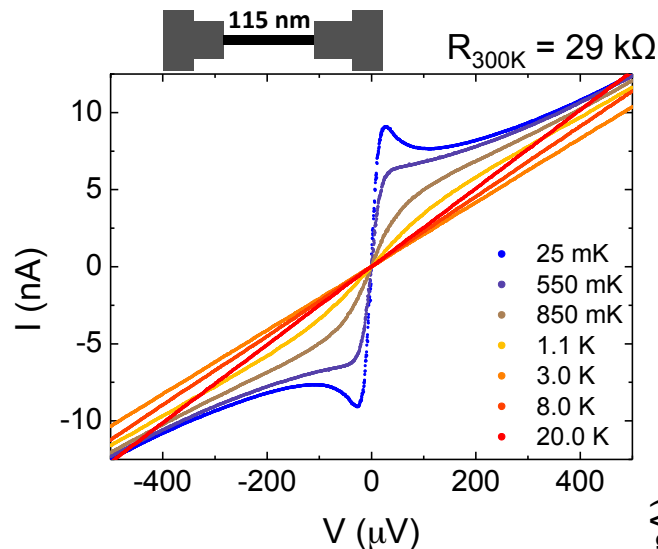
A. Bezryadin et al., J. Phys.: Condens. Matter **20** (2008) 043202

B = 0 T

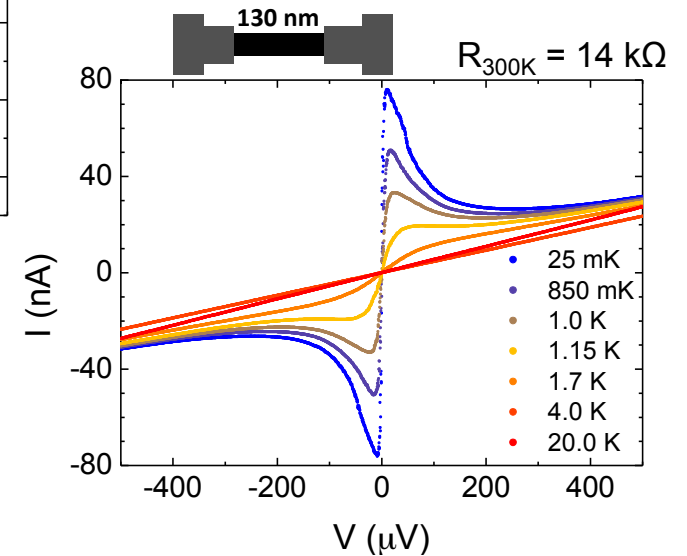
I(V) characteristics at B=0



- ❖ voltage bias
→ descending part of I(V)s accessible
- ❖ behavior different from superconducting films



critical current *density*
decreases with width



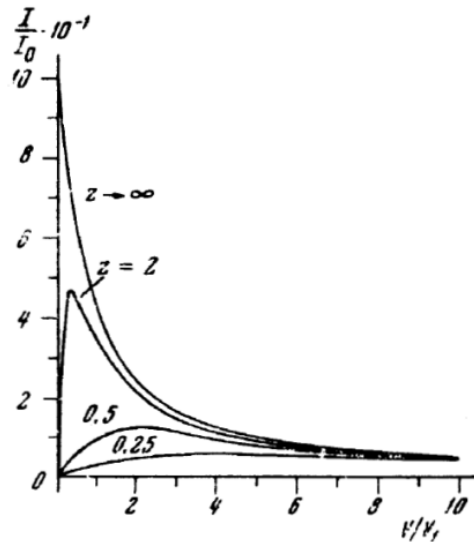
- ❖ consistent with phase slip scenario
- ❖ I(V)s very similar to that of small Josephson junctions

I(V) characteristics, behavior of small Josephson junctions

THE JOSEPHSON EFFECT IN SMALL TUNNEL CONTACTS

Yu. M. IVANCHENKO and L. A. ZIL'BERMAN

Sov. Phys. JETP **28**, 1272 (1969)



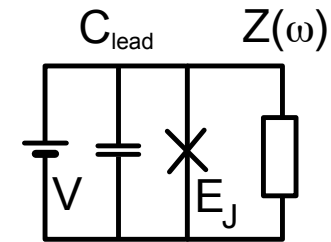
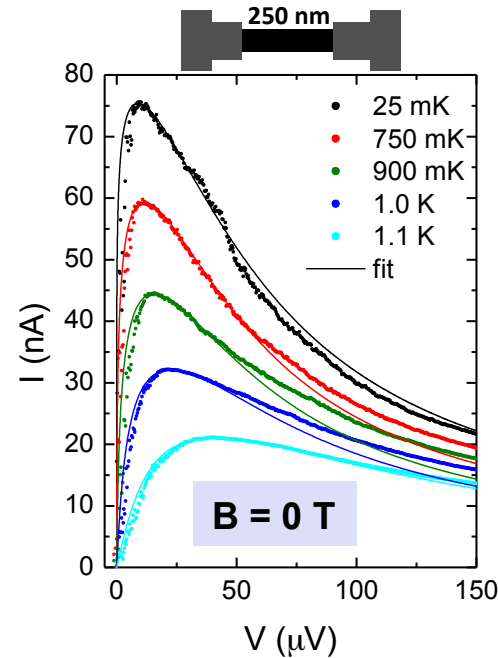
pure Ohmic damping,
phase fluctuations:

$$I(V_B) = I_0 \operatorname{Im} \left[\frac{I_{1-2i\beta eV_B/\hbar R_B}(\beta E_J)}{I_{-2i\beta eV_B/\hbar R_B}(\beta E_J)} \right]$$

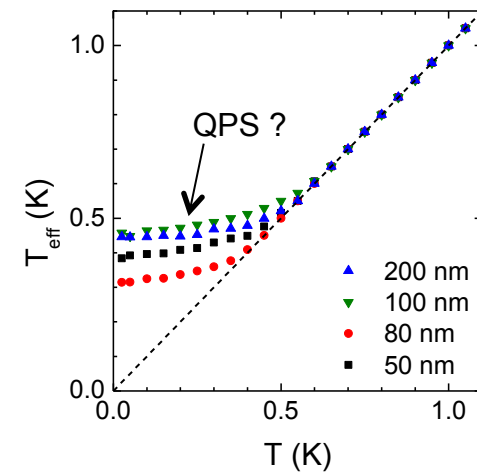
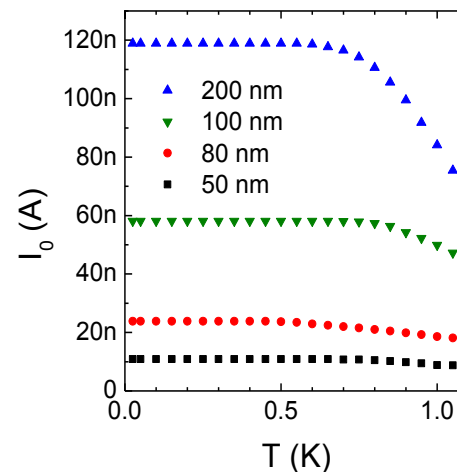
$$V_B = V + R_B I, \quad \beta = \frac{1}{k_B T}$$

see also Steinbach et al., Phys. Rev. Lett. **87**, 13 (2001)

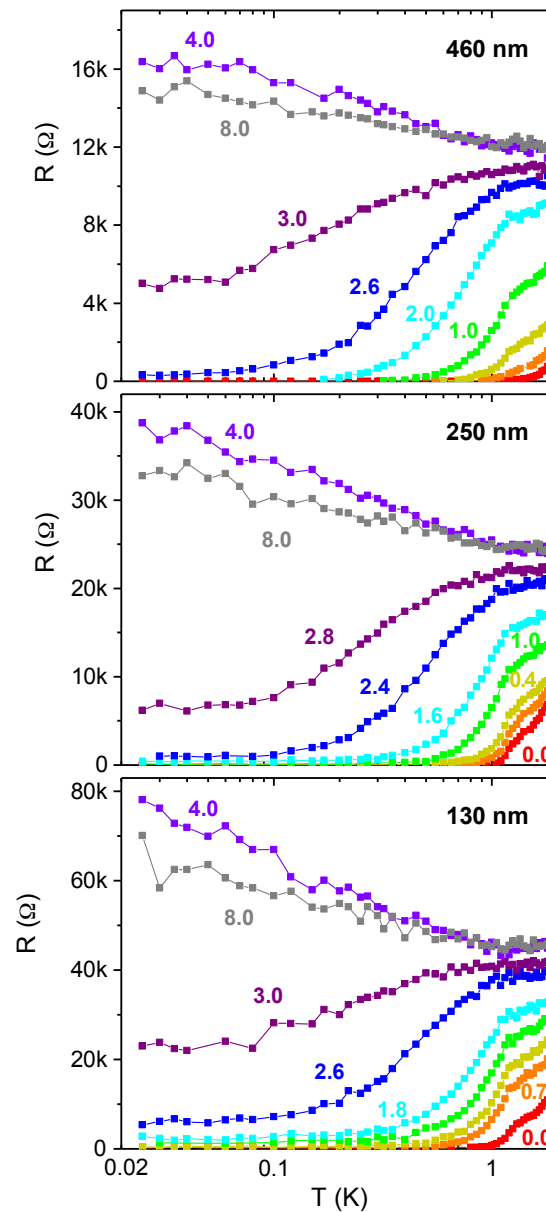
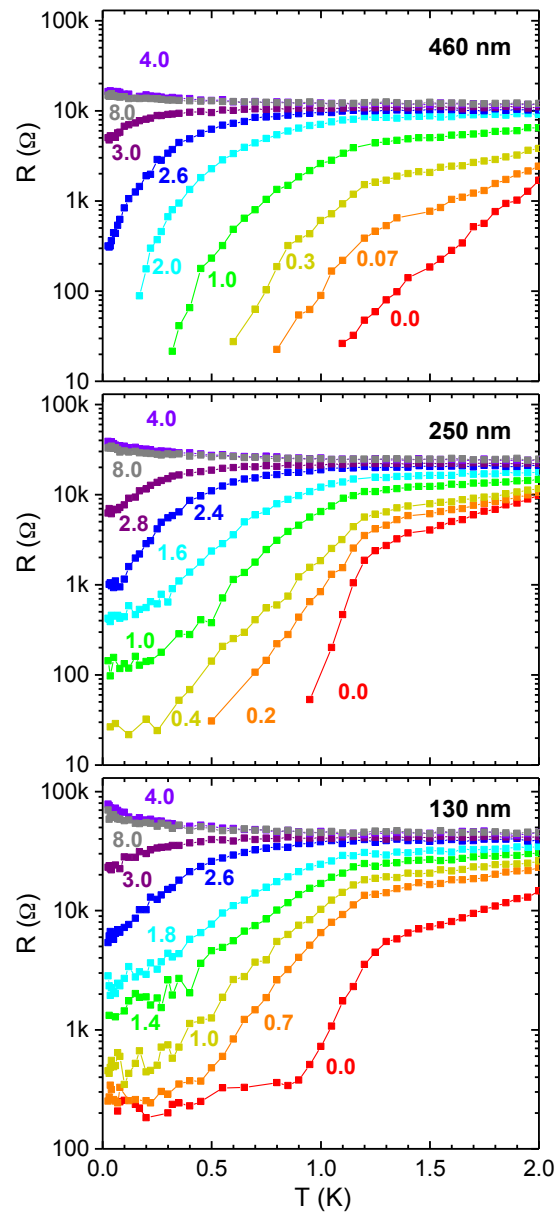
fit parameters: $I_0 = I_0(T), T = T_{eff}(T)$



model describes
diffusive motion
resulting from
thermal noise in
the ohmic environ-
ment of the junction



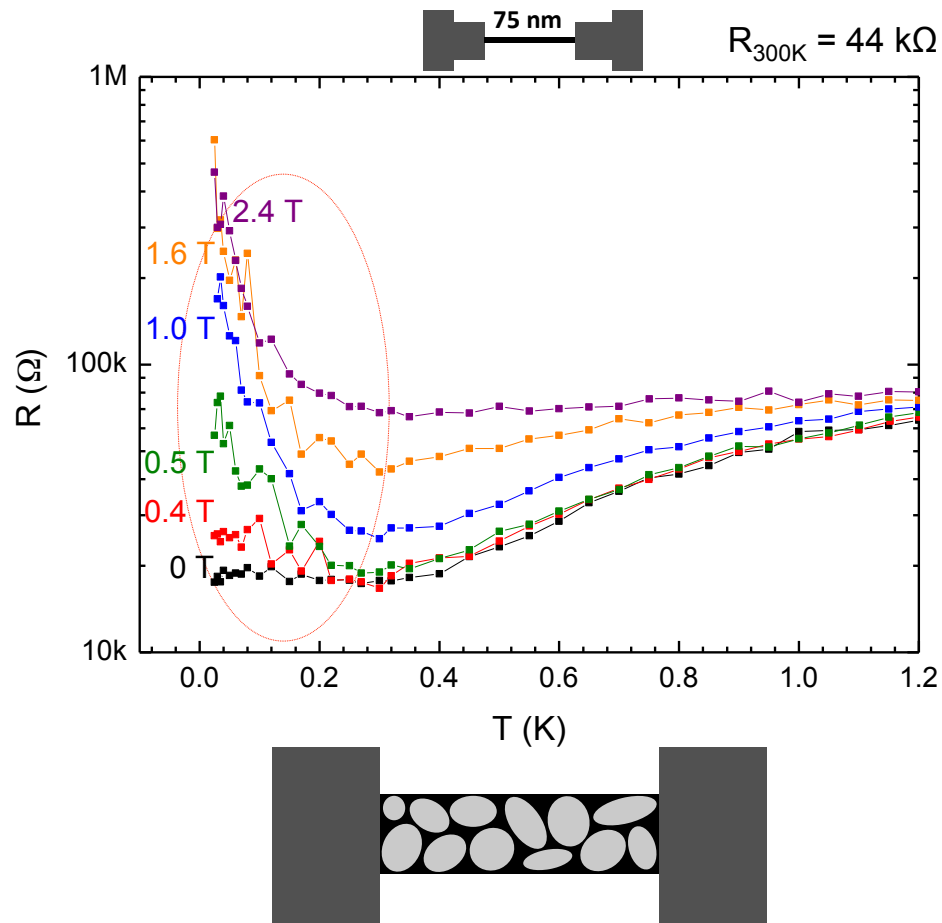
R(T) in perpendicular magnetic field for wider samples



- saturating R at low T and B
- crossover to a weakly localized regime at high B
- **no formation** of highly insulating states

Cooper-pair insulator and superinsulator do not come from **local** conduction properties of the material, but require certain minimal size

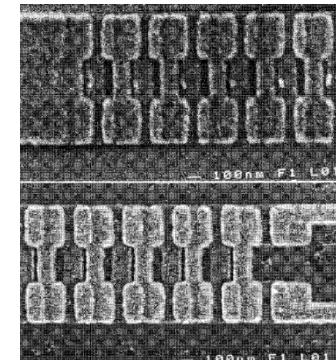
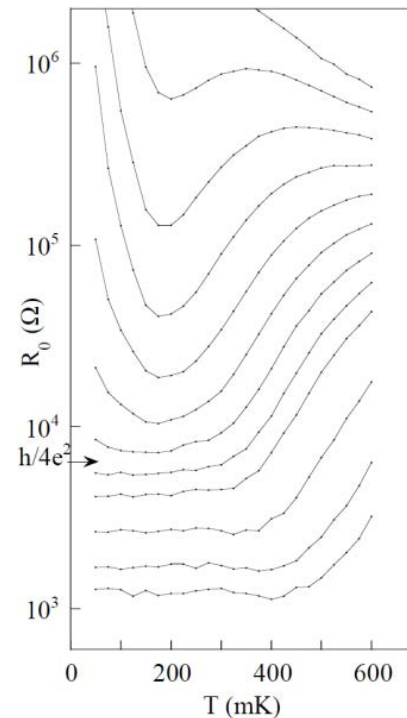
evolution of $R(T)$ in magnetic field



Superconducting and Insulating Behavior in One-Dimensional Josephson Junction Arrays

David B. Haviland, Karin Andersson, Peter Ågren

J. Low Temp. Phys. **118**, 5 (2000)



SEM image of two artificial SQUID arrays

- ❖ reentrant insulating behavior: understandable in terms of a magnetic field tuned E_J/E_C
- ❖ spontaneously formed random Josephson junction array? → compare to artificial JJ arrays

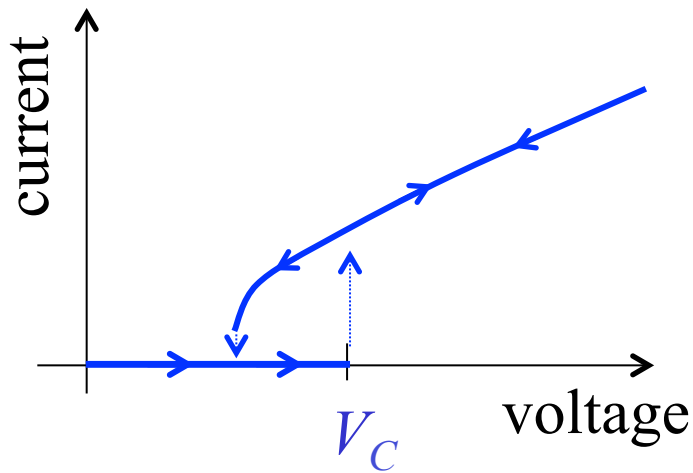
very similar behavior to that observed for one-dimensional Josephson junction arrays

charge-phase duality

$$\Delta Q \rightarrow 0$$

Coulomb Blockade of Cooper pair Tunneling

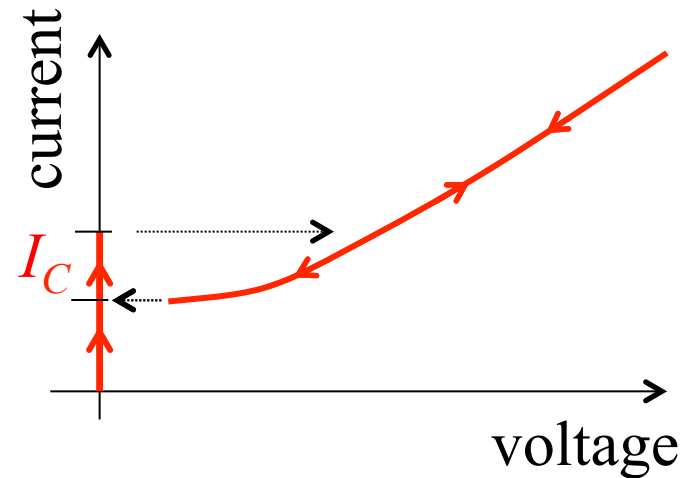
$$V = V_C \sin \chi \quad I = \frac{2e}{2\pi} \frac{d\chi}{dt}$$



$$\Delta \Phi \rightarrow 0$$

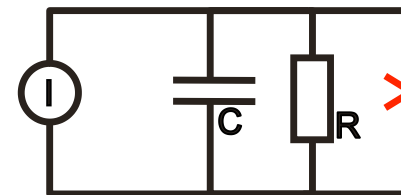
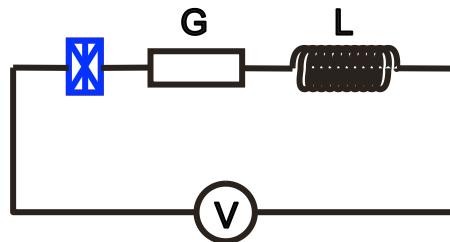
Josephson Effect

$$I = I_C \sin \phi \quad V = \frac{\Phi_0}{2\pi} \frac{d\phi}{dt}$$



Josephson junction acts as:

Non-linear capacitor

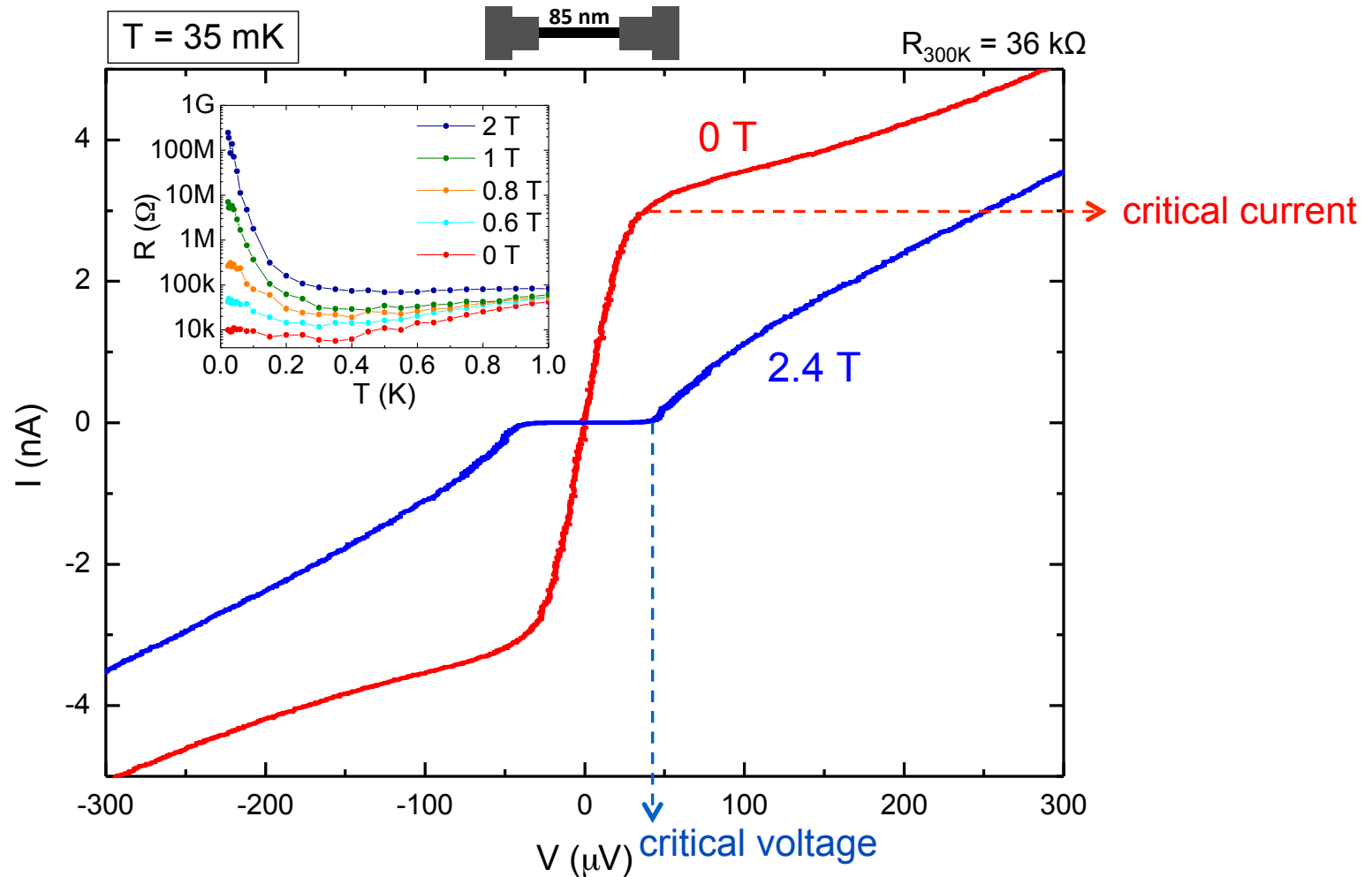


Non-linear inductor

evolution of $R(T)$ in magnetic field

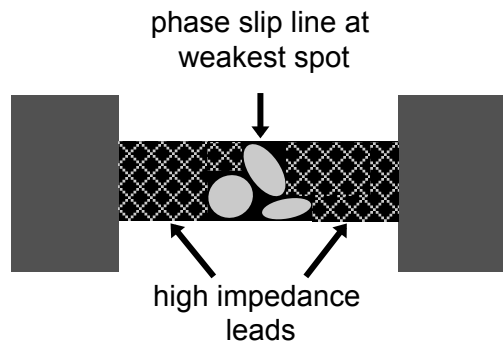
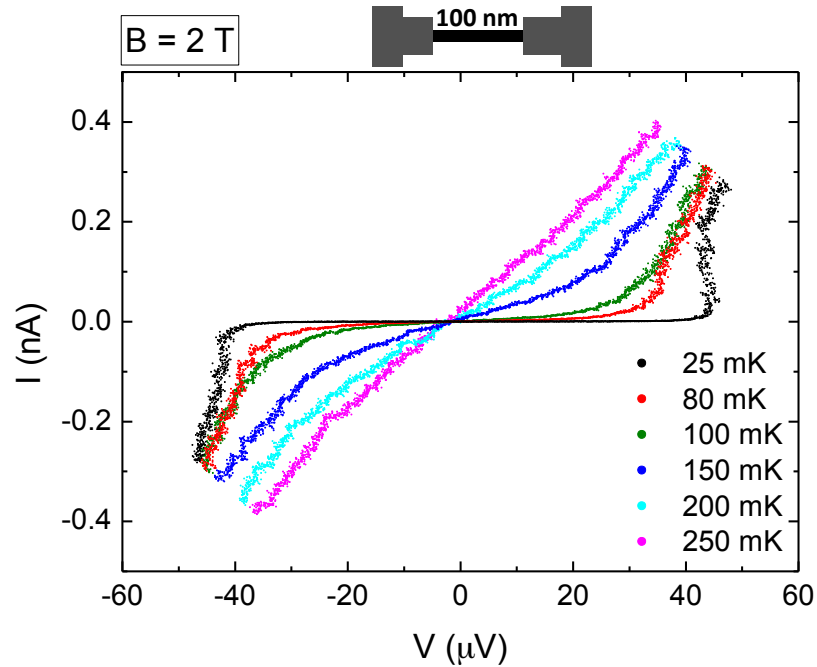
same film, different sample:

magnetic field induced superconductor-insulator transition



low T bias resistors $2 \times 50 \text{ k}\Omega$

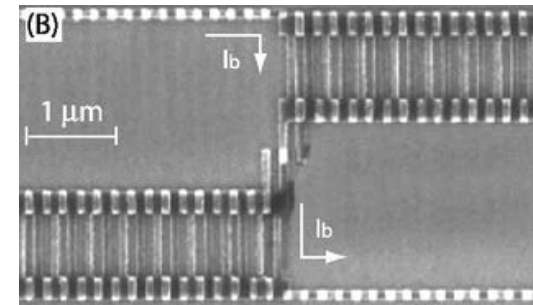
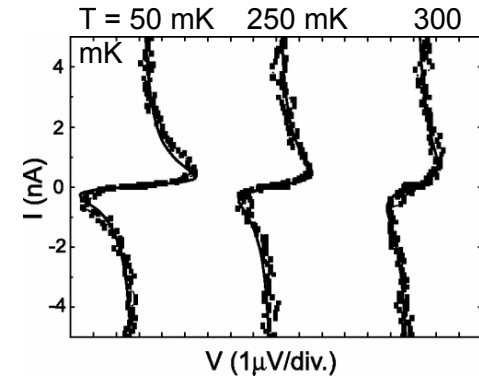
characteristics of the insulating state



Phase-Charge Duality of a Josephson Junction in a Fluctuating Electromagnetic Environment

S. Corlevi,¹ W. Guichard,^{1,2} F. W. J. Hekking,² and D. B. Haviland¹

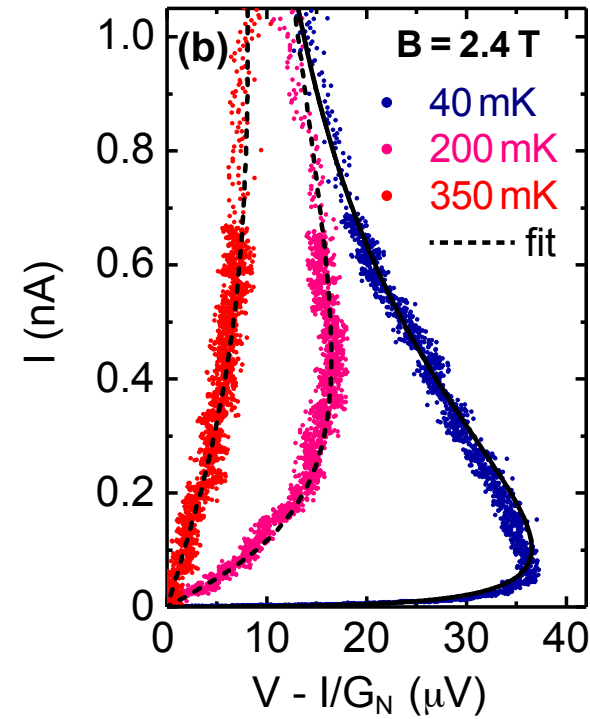
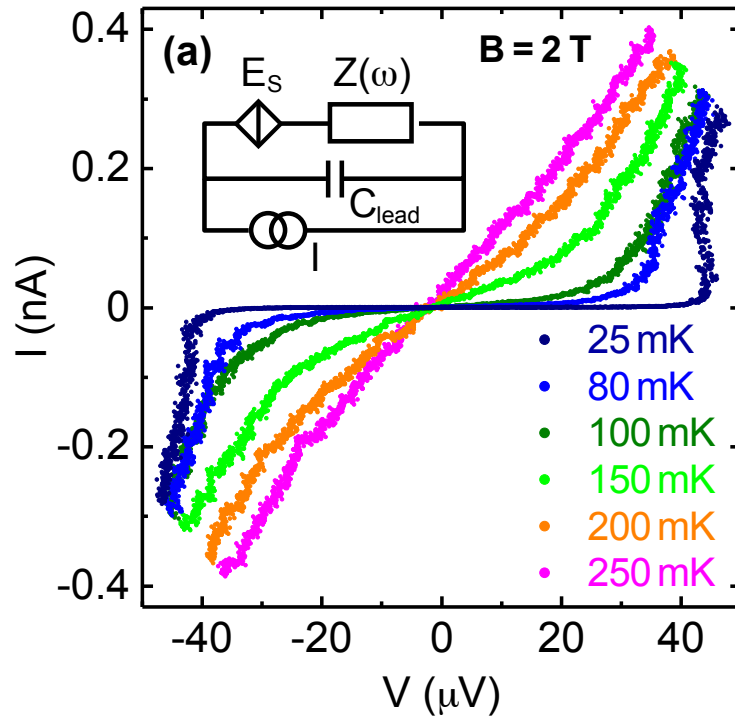
Phys. Rev. Lett. **97**, 096802 (2006)



SEM image of a single junction configuration

very similar behavior to that observed for a single Josephson junction in a high impedance environment

characteristics of the insulating state



subtract voltage in 'normal' state:

IV-curves can be described by *dual* Ivanchenko-Zilberman-model

